

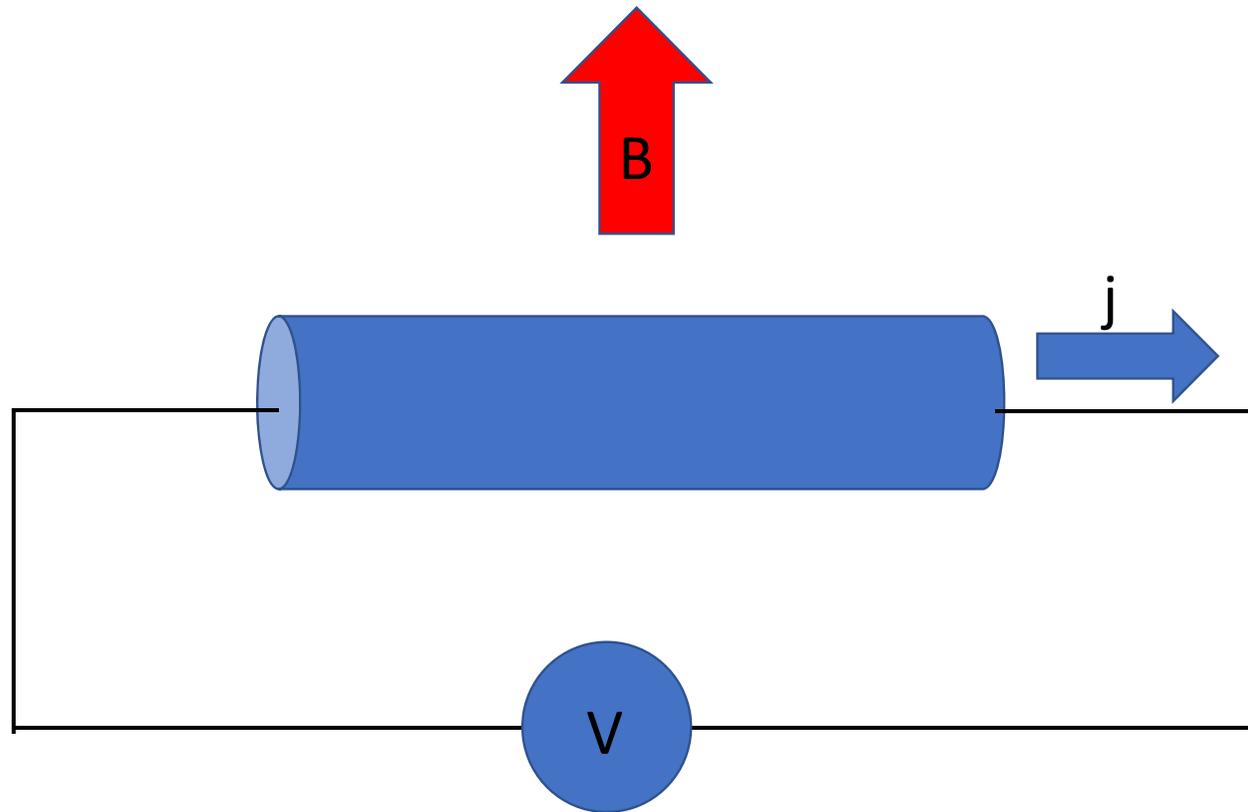
# Quadratic to linear magnetoresistance crossover and magneto-plasmons in graphene

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(2) Institute für Physikalische Chemie, Stuttgart University, Stuttgart, Germany

# Problem statement

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$$R = V/I$$
$$R(B) = ?$$

# Experimental evidence

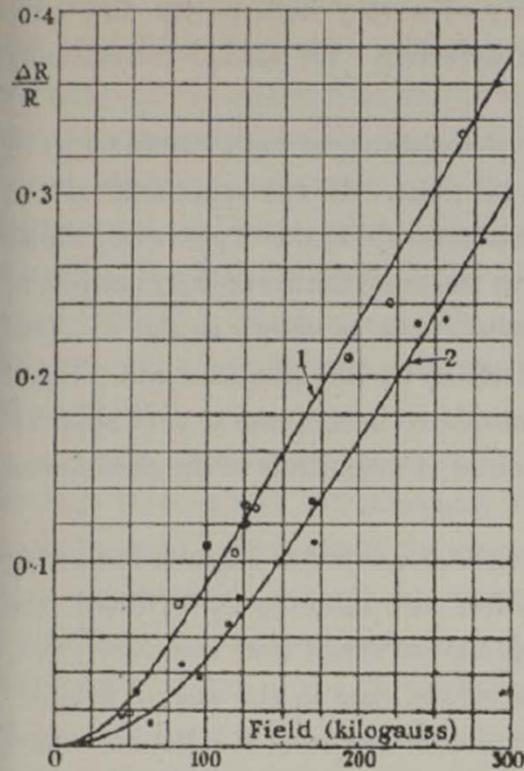


FIG. 6.—Silver  $H \perp I$ .

Curve 1—Ag annealed. Temperature of Liquid Nitrogen.

Curve 2—Ag hard. Temperature of Liquid Air.

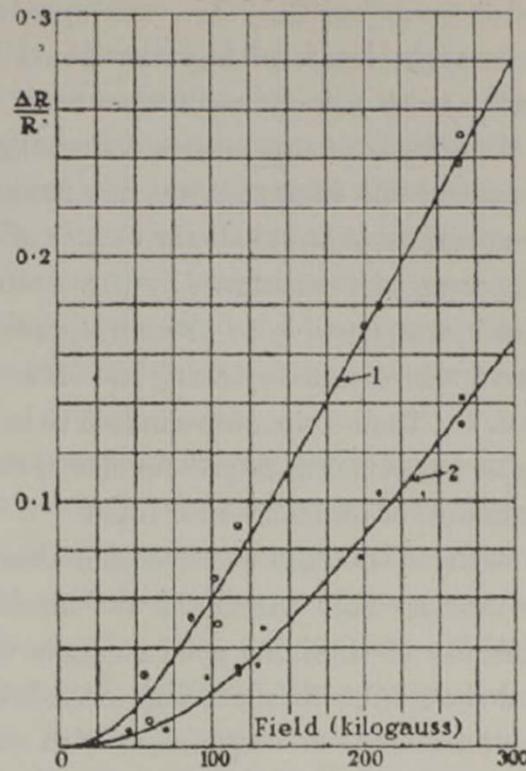


FIG. 7.—Gold  $H \perp I$ .

Curve 1—Au<sub>I</sub> soft. Temperature of Liquid Nitrogen.

Curve 2—Au<sub>II</sub> hard. Temperature of Liquid Air.

$$\frac{\Delta R}{R} = \beta \frac{H^2}{3H_k} \quad H \leq H_k,$$

$$\frac{\Delta R}{R} = \beta \left( H - H_k + \frac{H_k^2}{3H} \right) \quad H \geq H_k.$$

(2) The change of resistance in a transverse field at room temperature, at temperature of solid  $\text{CO}_2$  and ether and at the temperature of liquid nitrogen has been studied in the following metals: Li, Na, Cu, Ag, Au, Be, Mg, Zn, Cd,

Hg, Al, Ga, In, Tl, C, Ti, Ge, Zr, Sn, Pb, Th, V, As, Sb, Bi, Ta, Cr, Mo, Te, W; Mn, Fe, Ni, Pd, Pt; in a gold-silver alloy and in  $\text{Cu}_3\text{As}$ .

(4) It was found that in all the metals the change of resistance follows the same law which can be expressed by a formula which fits the experimental results quite well. This formula gives a square law in weak fields and a linear law in stronger fields.

(5) It has been shown that the physical change produced in a conductor by hardening and annealing has a strong influence on the phenomenon of change of resistance.

(6) The influence of the impurities is also very marked and was studied.

Kapitza P. and Rutherford Ernest. The change of electrical conductivity in strong magnetic fields. Part I. - Experimental results. 123. Proc. R. Soc. Lond. A (1929)

Patterson, Phil. Mag., vol. 3, p. 642 (1902)

# Disagreement with Boltzman kinetic theory

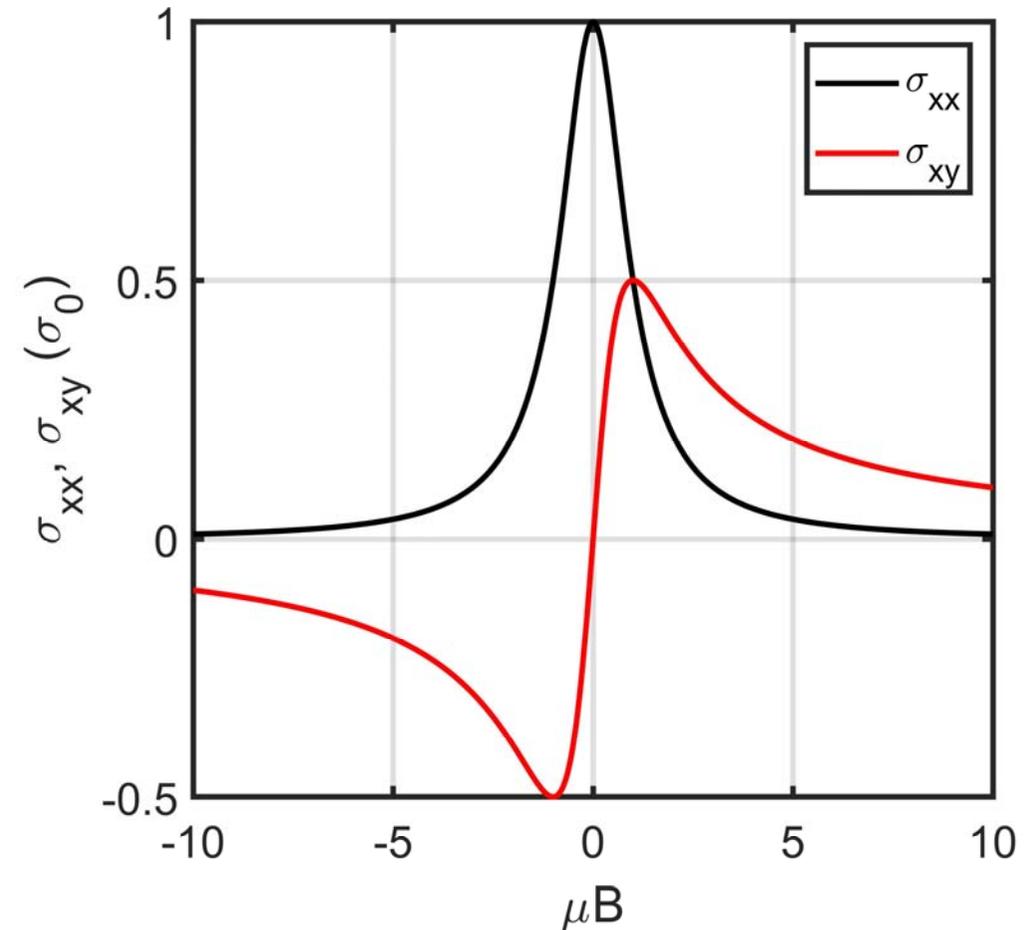
$$\mathbf{j} = \frac{en\mu}{1 + (\mu B)^2} \begin{pmatrix} 1 & -\mu B \\ \mu B & 1 \end{pmatrix} \cdot \mathbf{E}$$

$$\mathbf{j} = \frac{e^2 n \tau}{m} \frac{1}{1 + (\mu B)^2} \begin{pmatrix} 1 & -\mu B \\ \mu B & 1 \end{pmatrix} \cdot \mathbf{E}$$

$$\sigma_{xx} = \sigma_0 \frac{1}{1 + (\mu B)^2}$$

$$\sigma_{xy} = \sigma_0 \frac{\mu B}{1 + (\mu B)^2}$$

$$\mathbf{j} = \begin{pmatrix} \sigma_{xx} & -\sigma_{xy} \\ \sigma_{xy} & \sigma_{xx} \end{pmatrix} \cdot \mathbf{E} = \boldsymbol{\sigma} \cdot \mathbf{E}$$



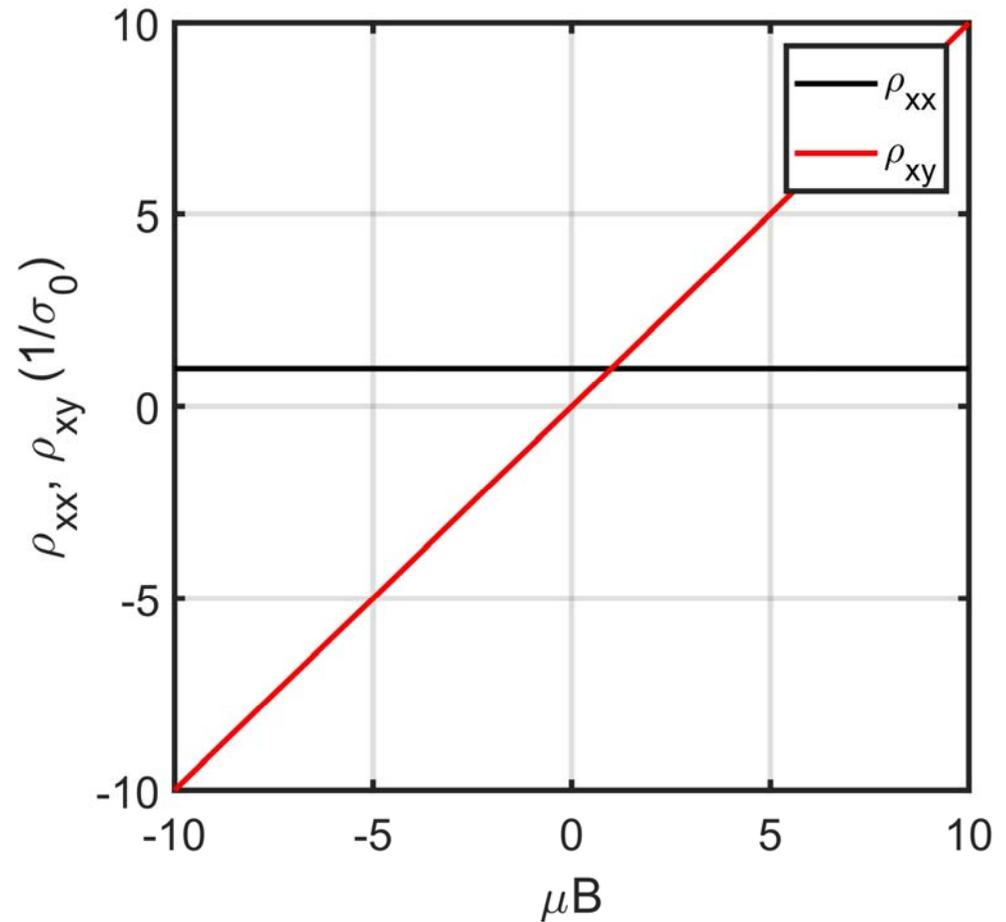
# Disagreement with Boltzman kinetic theory

$$\mathbf{E} = \rho \cdot \mathbf{j} = \sigma^{-1} \cdot \mathbf{j}$$

$$\rho = \frac{1}{\sigma_0} \begin{pmatrix} 1 & \mu B \\ -\mu B & 1 \end{pmatrix}$$

$$\rho_{xx} = \frac{1}{\sigma_0}$$

$$\rho_{xy} = \frac{\mu B}{\sigma_0} = \frac{B}{en}$$



# Historical perspectives

- Abrikosov, impurities, scattering centers

$$\sigma_{zz} = \frac{1}{(2\pi)^3} \left( \frac{e^2 H}{c} \right)^2 \frac{1}{N_i},$$

$$\sigma_{xx} = \sigma_{yy} = \frac{ecN_i}{\pi H}.$$

A. A. Abrikosov Soviet Physics JETP 29 (1969) 746.

$$\rho_{xx} = \frac{HN_i}{\pi ecn_0^2} \frac{\sinh(1/\theta)}{\cosh(m/\theta) + \cosh(m/\theta)}.$$

A. A. Abrikosov Phys. Rev. B. 60 (1999) 4231.

- Linear, positive MR in silver chalcogenides due to the gapless and linear dispersion

$$\rho_{xx} = \frac{1}{2\pi} \left( \frac{e^2}{\epsilon_\infty v} \right)^2 \ln \epsilon_\infty \frac{N_i}{ecn_0^2} H.$$

A. A. Abrikosov Phys. Rev. B. 58 (1998) 2788.

- Alekseev, Phys. Rev. B 95 (2017) 165410, compensated semimetals
  - Electron-hole fluid in a confined geometry, Phys. Rev. B 97 (2018) 085109.
- Gopinadhan et al., Nat. Comm. 6 (2015) 8337 – conductivity inhomogeneities
- Jervis and Johnson, Solid-State Electronics 13 (1970) 181, geometrical magnetoresistance,
- Kapitza, random disturbances (quadratic to linear crossover)

$$\frac{\Delta R}{R_0} = (\xi \mu_H B_0)^2,$$

# Historical perspectives

- Khouri et al., Phys. Rev. Lett. 117 (2016) 256601, linear MR in ultra-high mobility GaAs QW

PRL 117, 256601 (2016)

PHYSICAL REVIEW LETTERS

week ending  
16 DECEMBER 2016



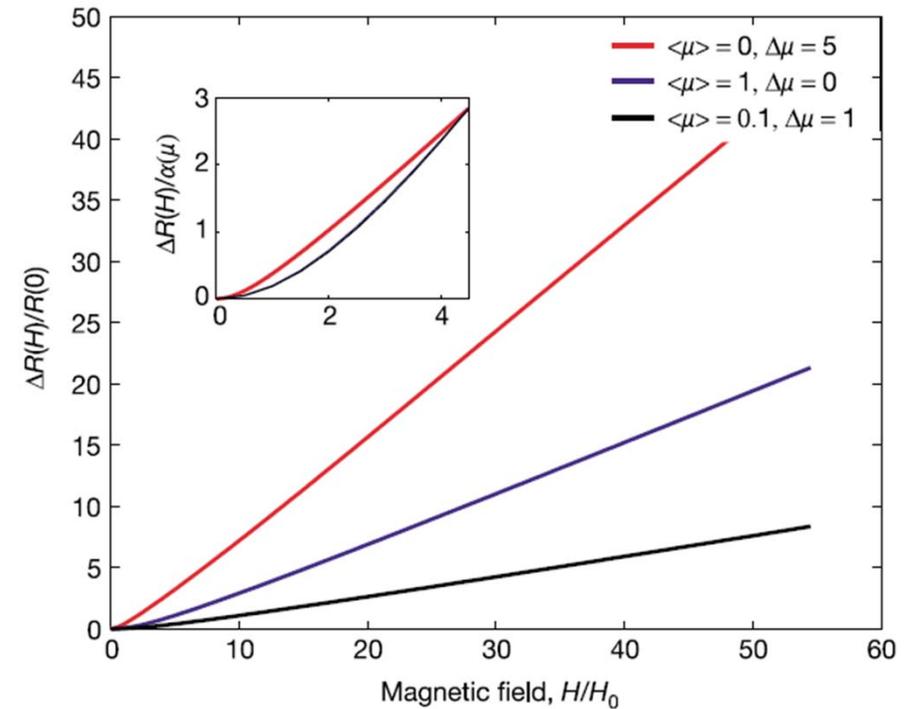
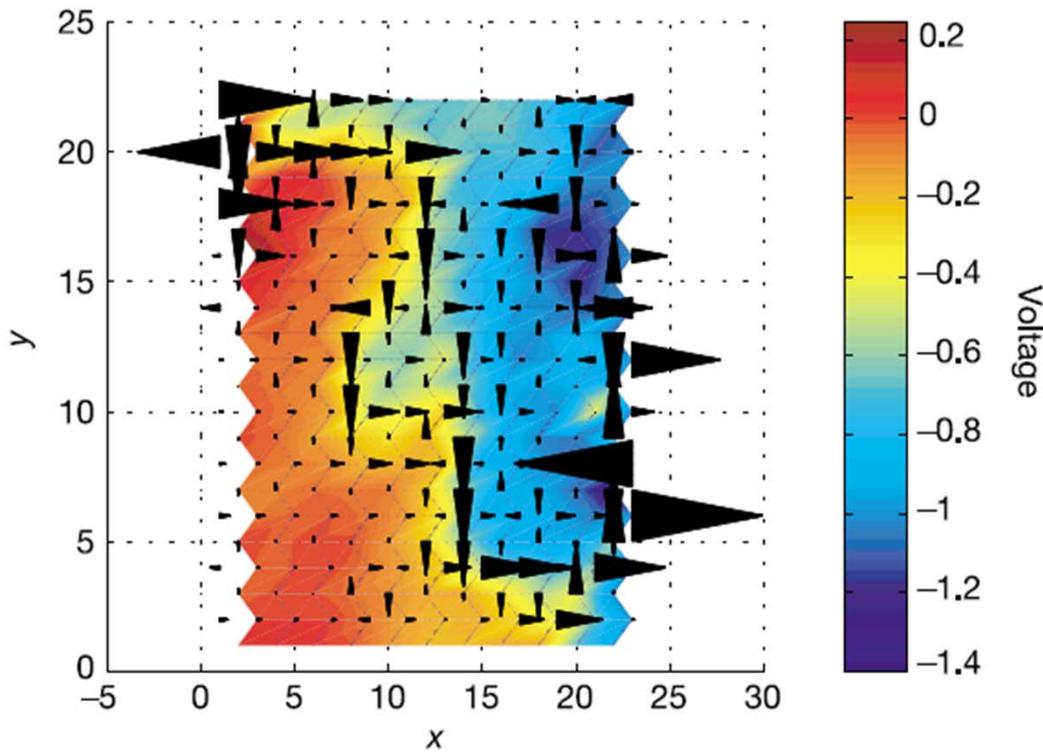
## Linear Magnetoresistance in a Quasifree Two-Dimensional Electron Gas in an Ultrahigh Mobility GaAs Quantum Well

T. Khouri,<sup>1,2,\*</sup> U. Zeitler,<sup>1,2</sup> C. Reichl,<sup>3</sup> W. Wegscheider,<sup>3</sup> N. E. Hussey,<sup>1,2</sup> S. Wiedmann,<sup>1,2,†</sup> and J. C. Maan<sup>1,2</sup>  
<sup>1</sup>High Field Magnet Laboratory (HFML-EMFL), Radboud University, Toernooiveld 7, 6525 ED Nijmegen, The Netherlands  
<sup>2</sup>Radboud University, Institute of Molecules and Materials, Heyendaalseweg 135, 6525 AJ Nijmegen, The Netherlands  
<sup>3</sup>Laboratory for Solid State Physics, ETH Zürich, 8093 Zürich, Switzerland  
(Received 21 October 2016; published 14 December 2016)

We report a high-field magnetotransport study of an ultrahigh mobility ( $\bar{\mu} \approx 25 \times 10^6 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ )  $n$ -type GaAs quantum well. We observe a strikingly large linear magnetoresistance (LMR) up to 33 T with a magnitude of order  $10^5\%$  onto which quantum oscillations become superimposed in the quantum Hall regime at low temperature. LMR is very often invoked as evidence for exotic quasiparticles in new materials such as the topological semimetals, though its origin remains controversial. The observation of such a LMR in the “simplest system”—with a free electronlike band structure and a nearly defect-free environment—excludes most of the possible exotic explanations for the appearance of a LMR and rather points to density fluctuations as the primary origin of the phenomenon. Both, the featureless LMR at high  $T$  and the quantum oscillations at low  $T$  follow the empirical resistance rule which states that the longitudinal conductance is directly related to the derivative of the transversal (Hall) conductance multiplied by the magnetic field and a constant factor  $\alpha$  that remains unchanged over the entire temperature range. Only at low temperatures, small deviations from this resistance rule are observed beyond  $\nu = 1$  that likely originate from a different transport mechanism for the composite fermions.

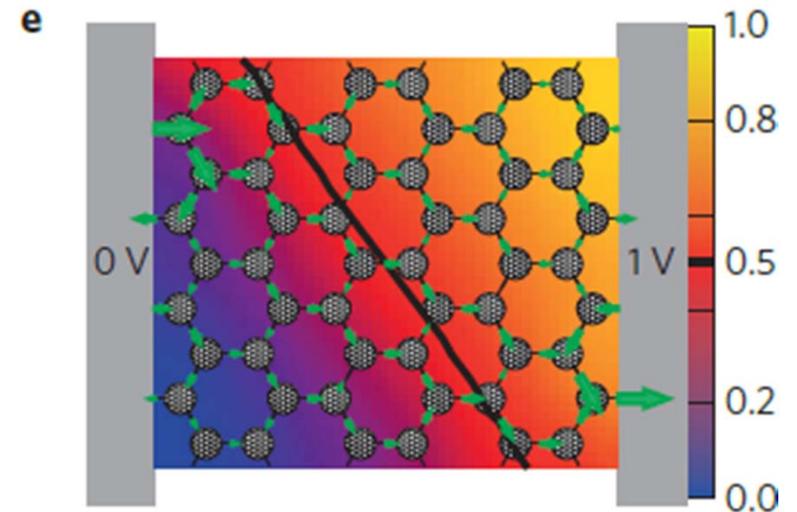
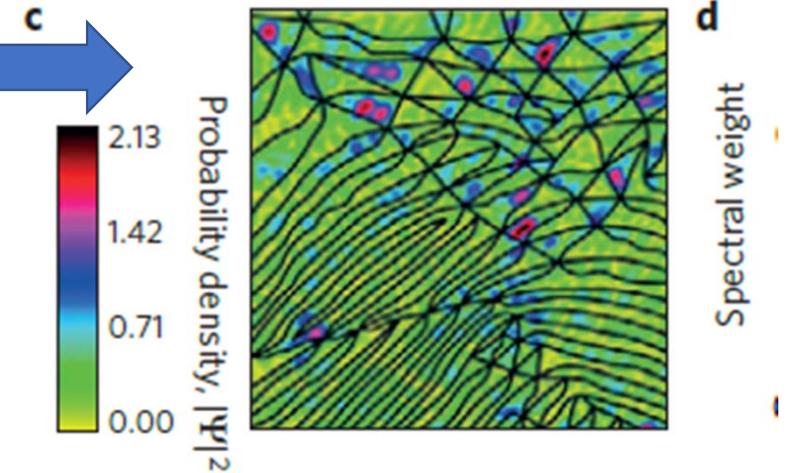
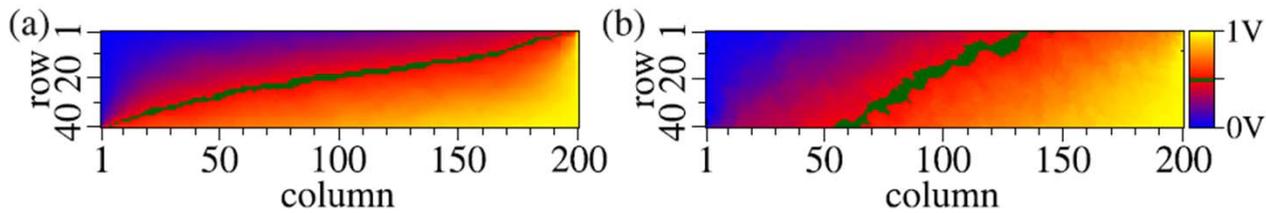
# Historical perspectives

- M.M.Parish, P.B.Littlewood, Nature 426 (2003) 162, Non-saturating magnetoresistance in heavily disordered semiconductors



# Historical perspectives

- Kisslinger et al., Nat. Phys. 11 (2015) 650...conductivity fluctuations
- Kisslinger et al., Phys. Rev. B 95 (2017) 024204



# Our theoretical model

$$\mathbf{j} = \frac{en\mu}{1 + (\mu B)^2} \begin{pmatrix} 1 & -\mu B \\ \mu B & 1 \end{pmatrix} \cdot \mathbf{E}$$

$$\mathbf{E} = -\nabla\varphi$$

$$\nabla \cdot \mathbf{j} = 0$$

$$\nabla \cdot \left[ \frac{en(\mathbf{r})\mu(\mathbf{r})}{1 + (\mu(\mathbf{r})B)^2} \begin{pmatrix} 1 & -\mu(\mathbf{r})B \\ \mu(\mathbf{r})B & 1 \end{pmatrix} \right] \cdot \nabla\varphi = 0$$

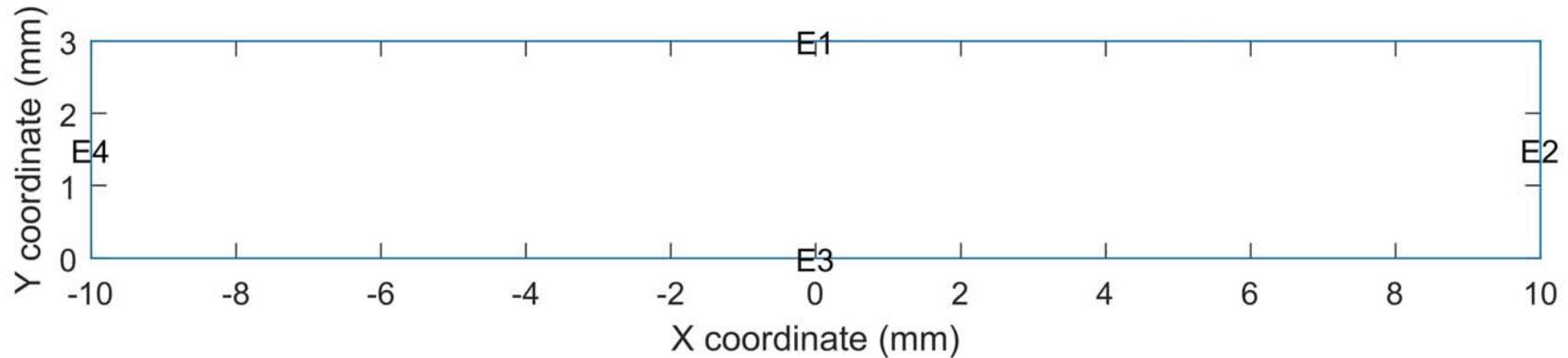
$$\varphi(L) = 0, \varphi(R) = 1V$$

$$\mathbf{j} \cdot \mathbf{n} = 0 \quad \text{at } \partial\Omega \setminus \{L, R\}$$

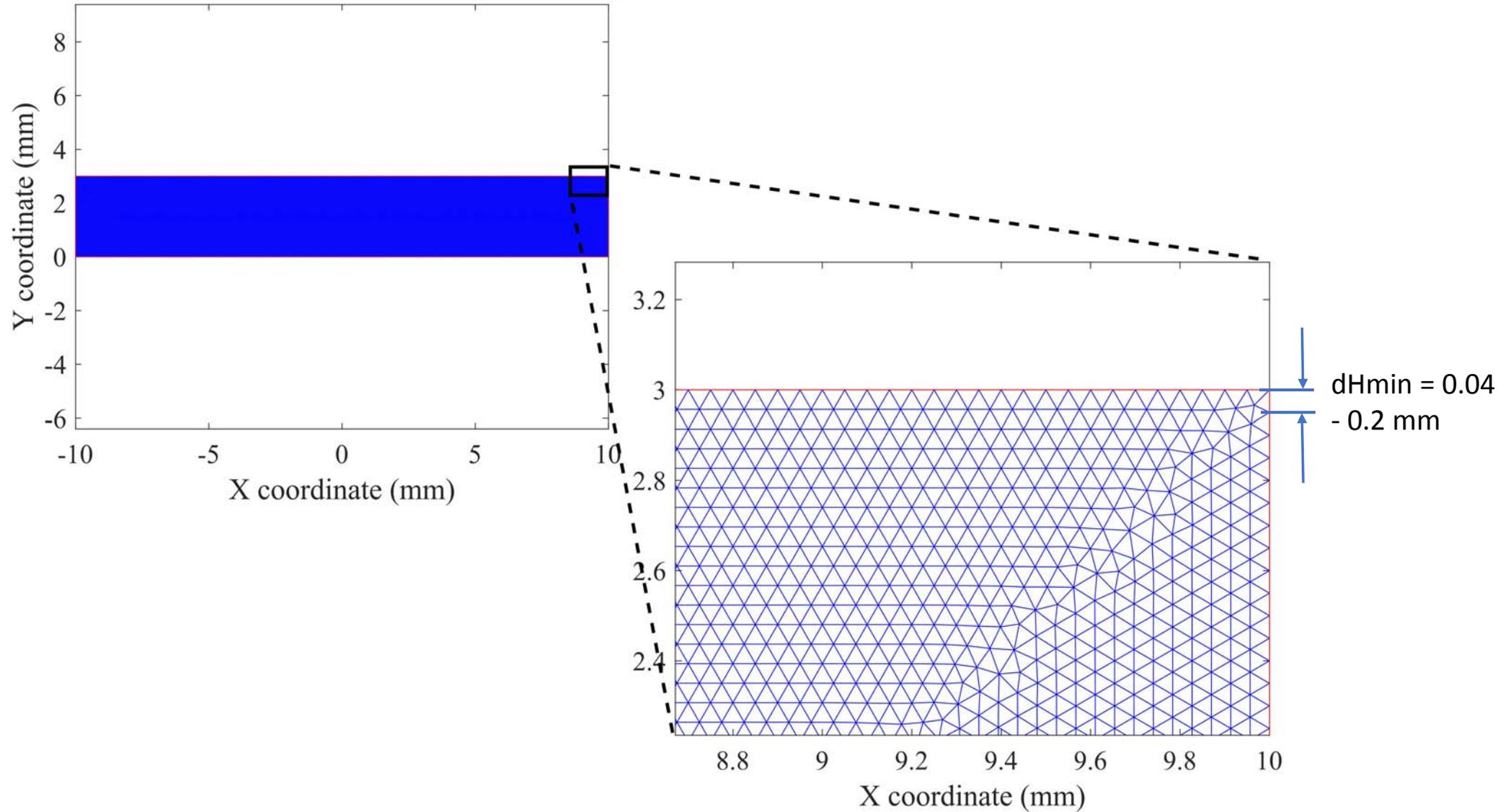
# Numerical implementation

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- Finite element method
- Simple rectangular geometry
- Edges of the sample are labeled E1, E2, E3 and E4
- Boundary conditions applied to the edges E1..E4

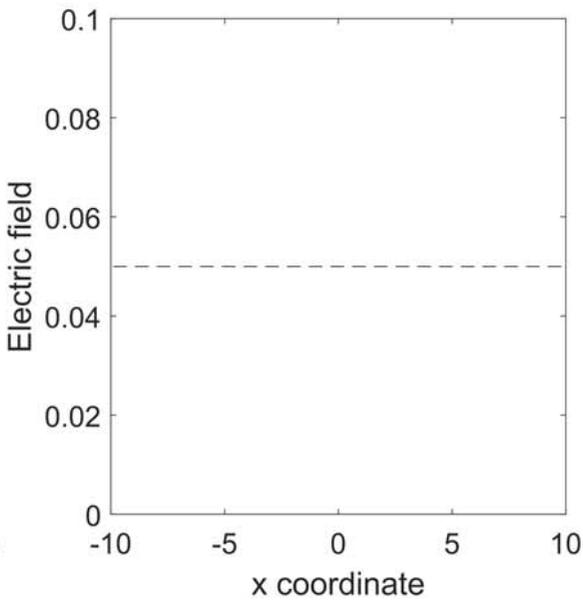
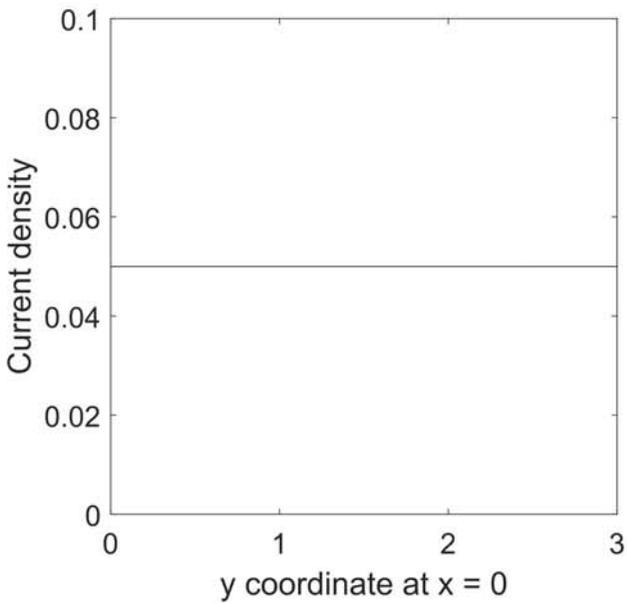
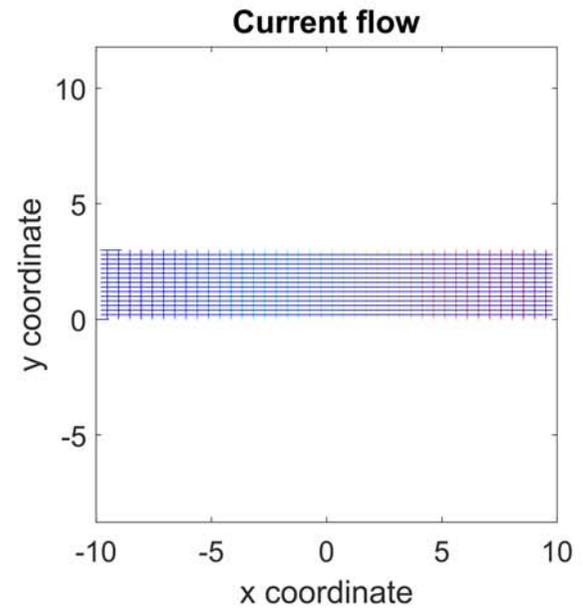
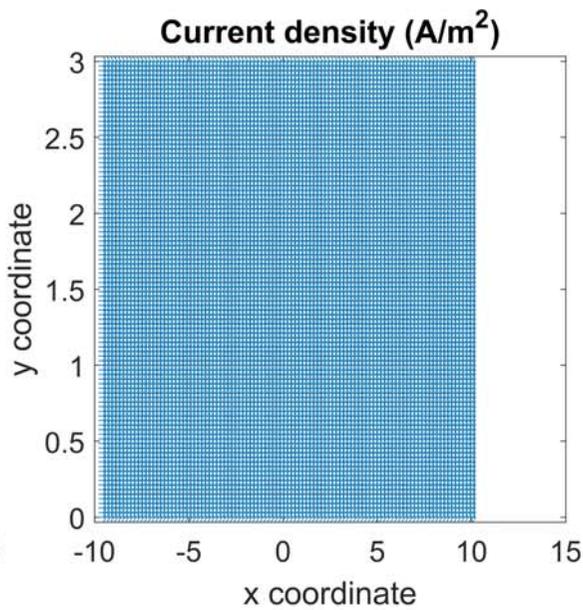
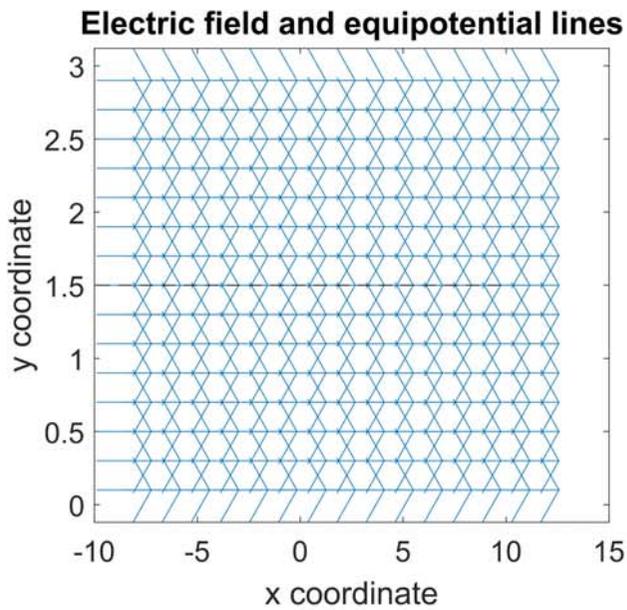
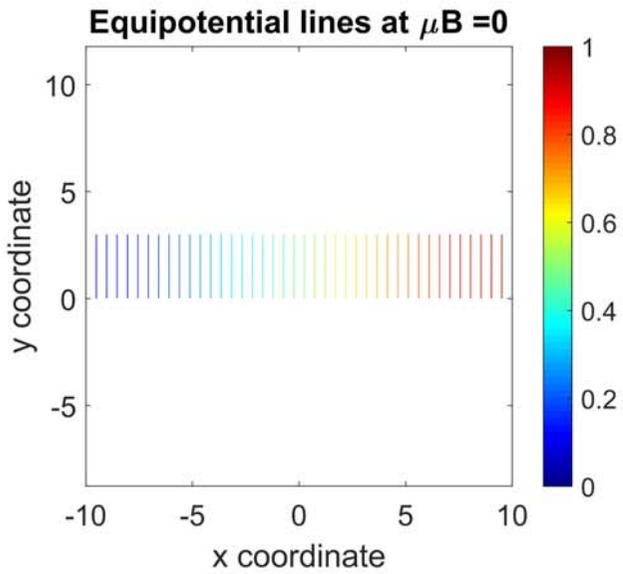


# Triangulation

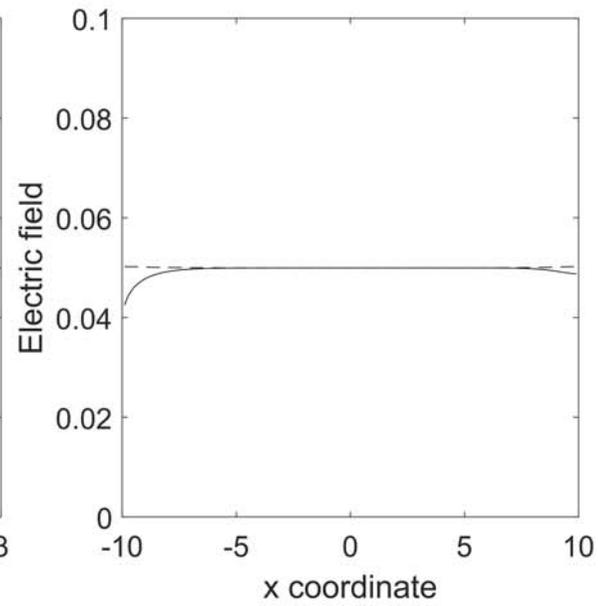
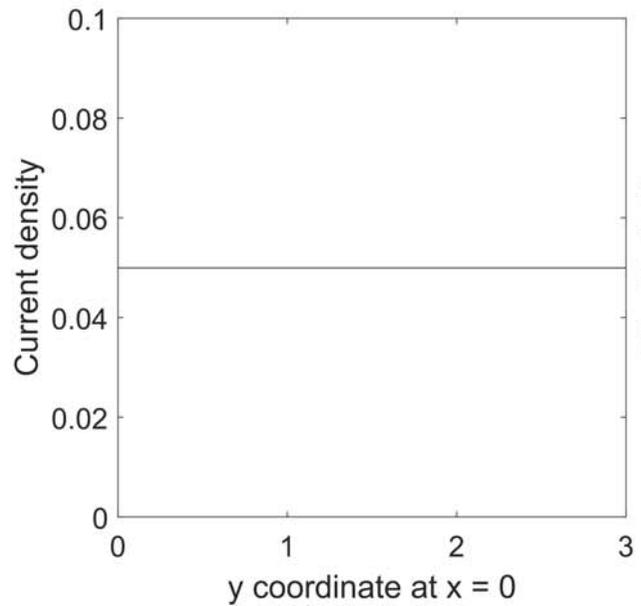
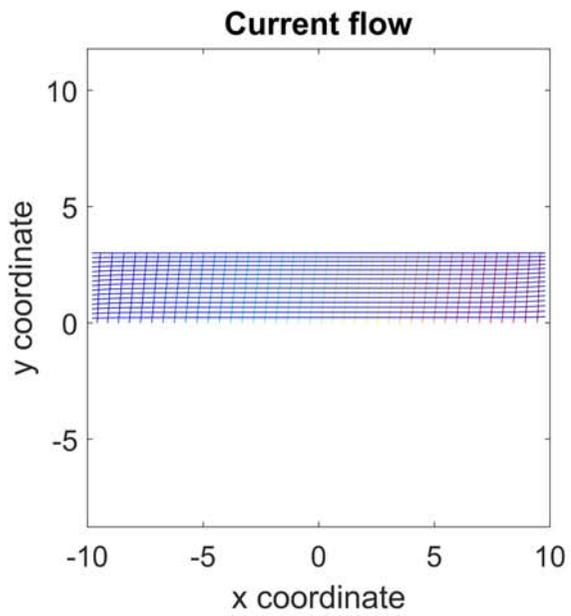
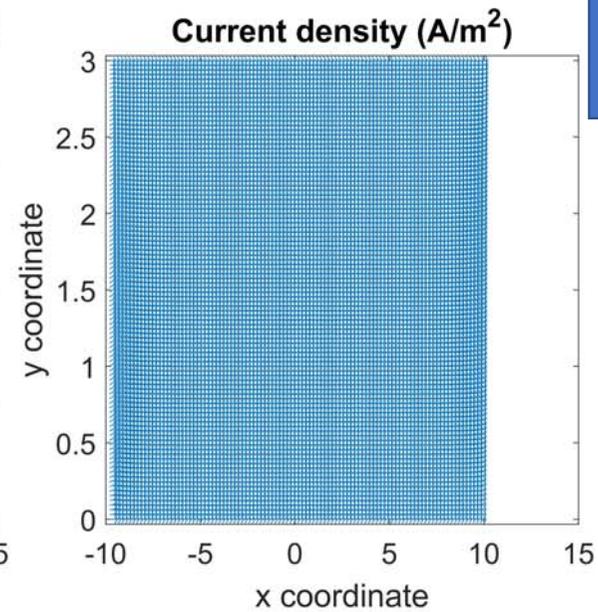
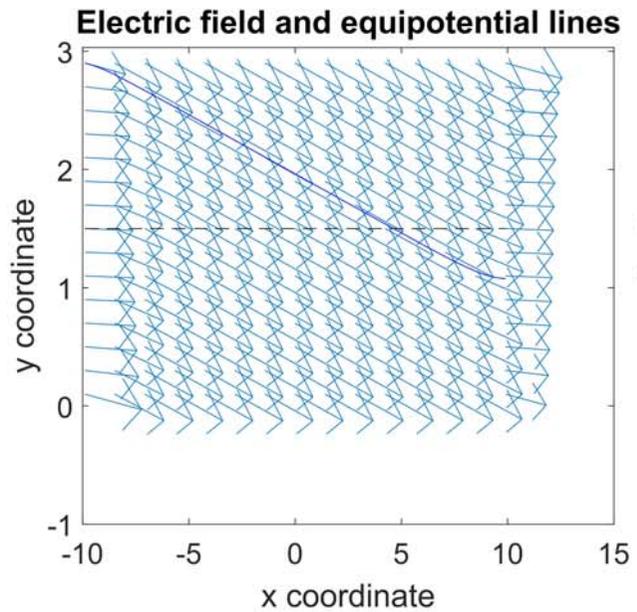
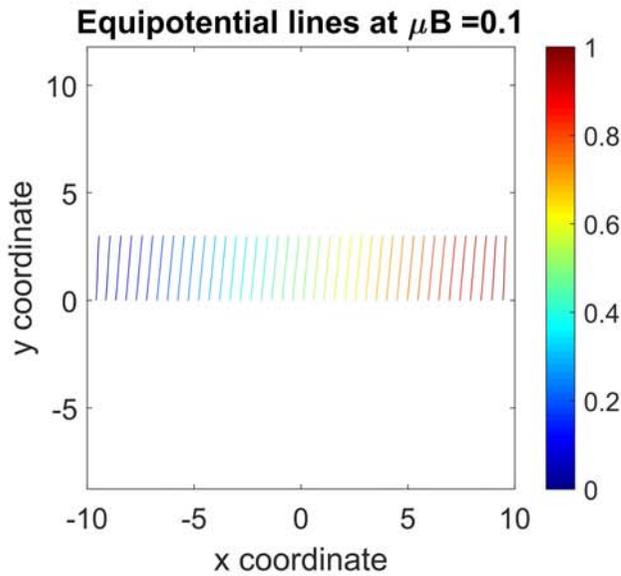


Results in an ideal  
conductor  
(no disorder)

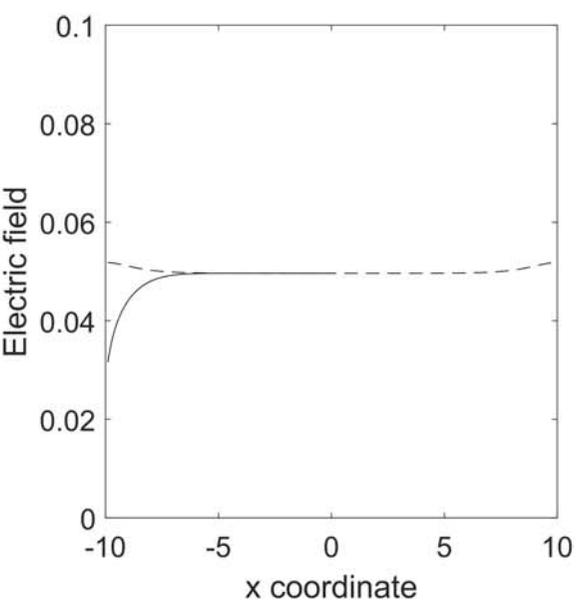
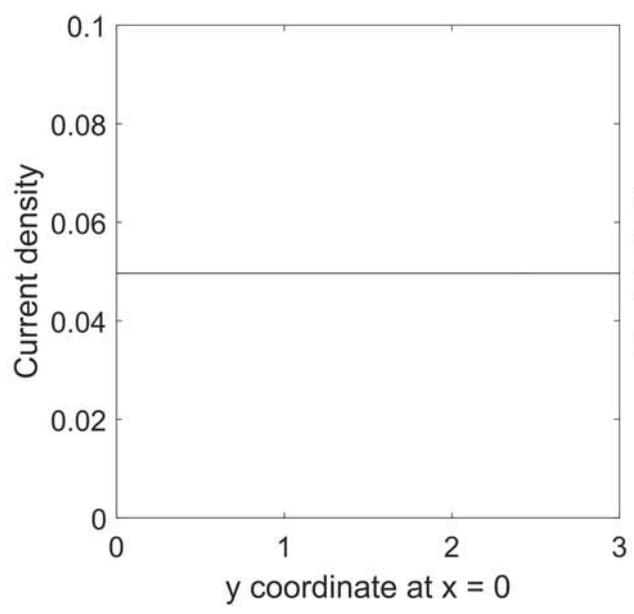
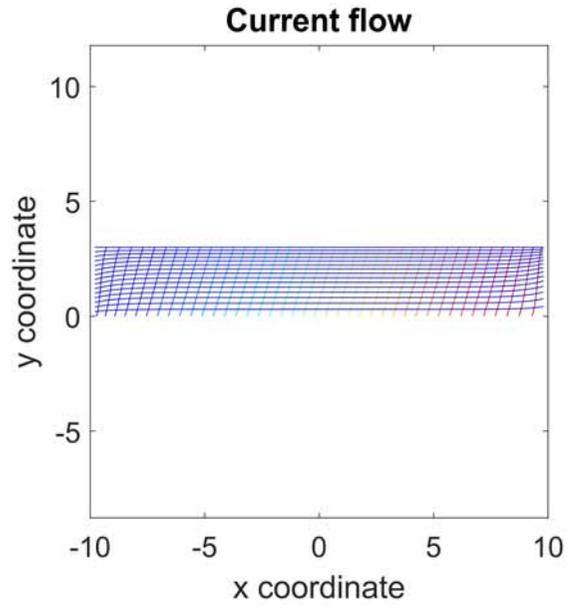
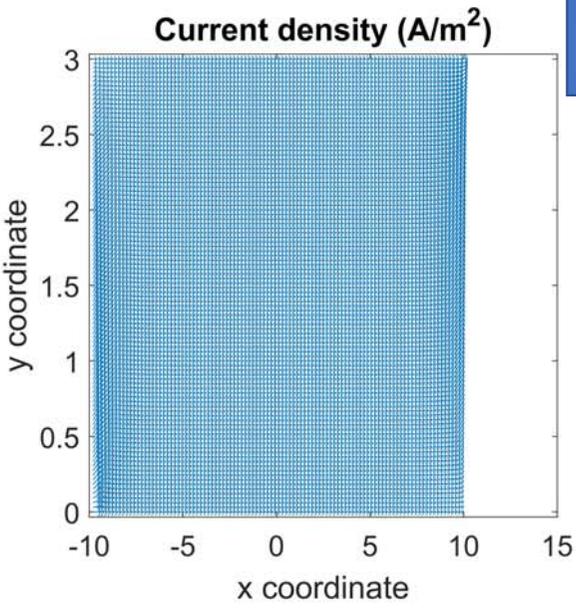
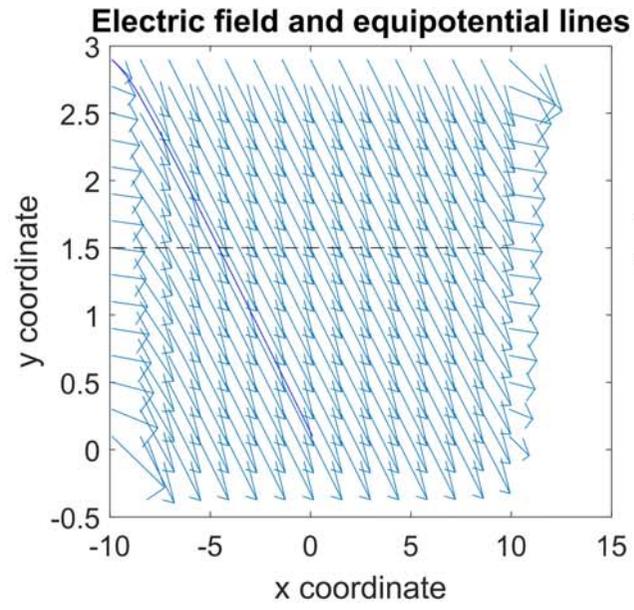
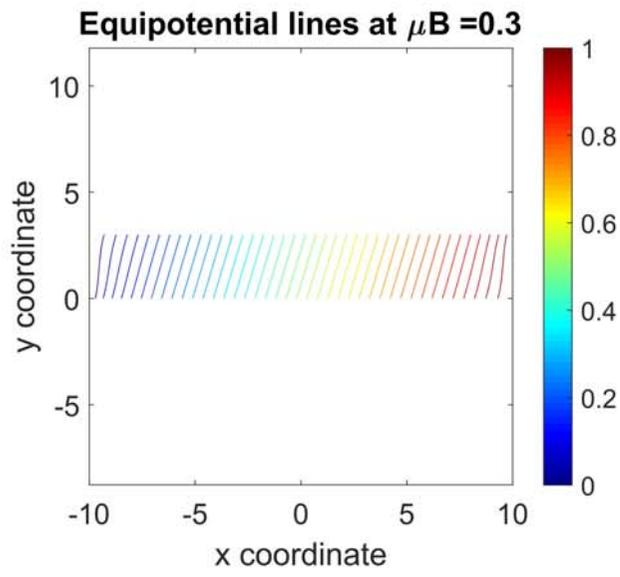
$\mu B = 0$



$\mu B = 0.1$

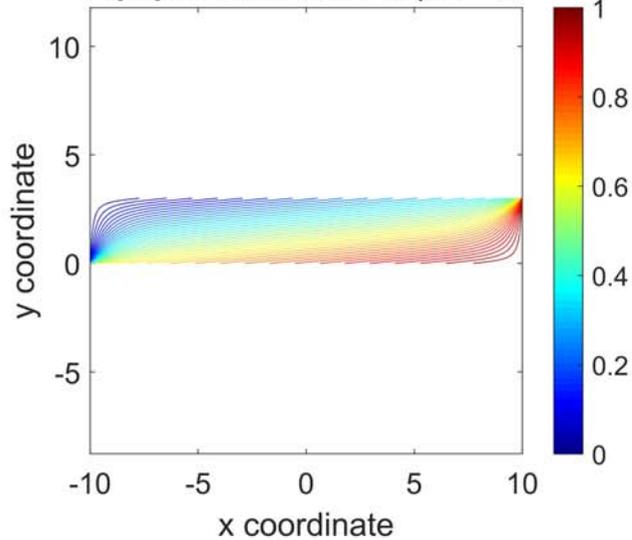


$\mu B = 0.3$

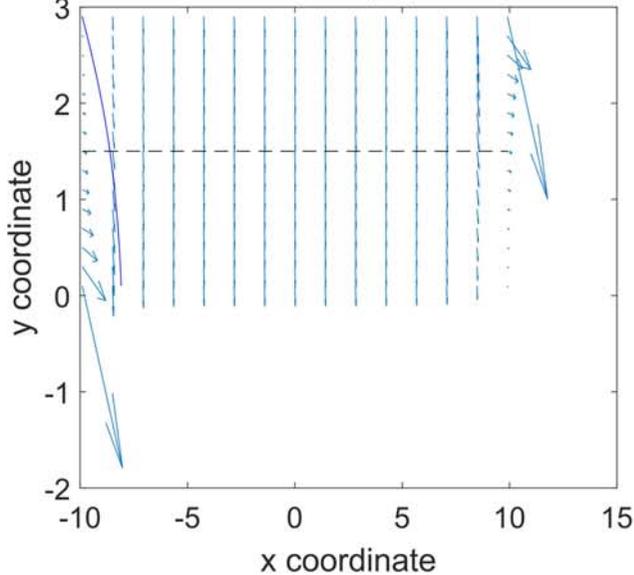


$\mu B = 10$

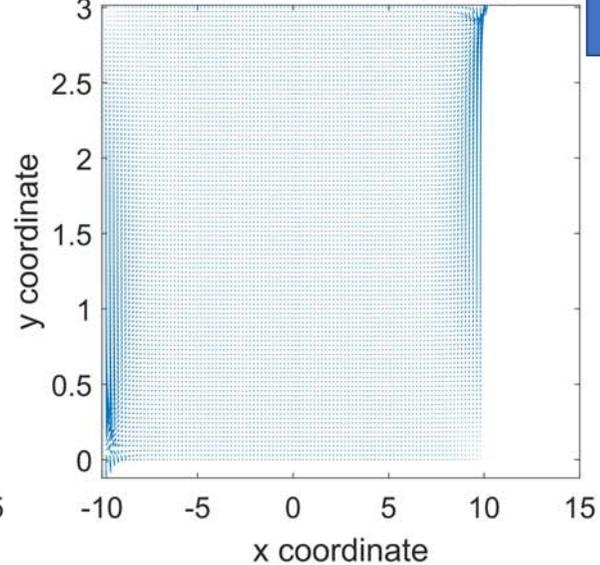
Equipotential lines at  $\mu B = 10$



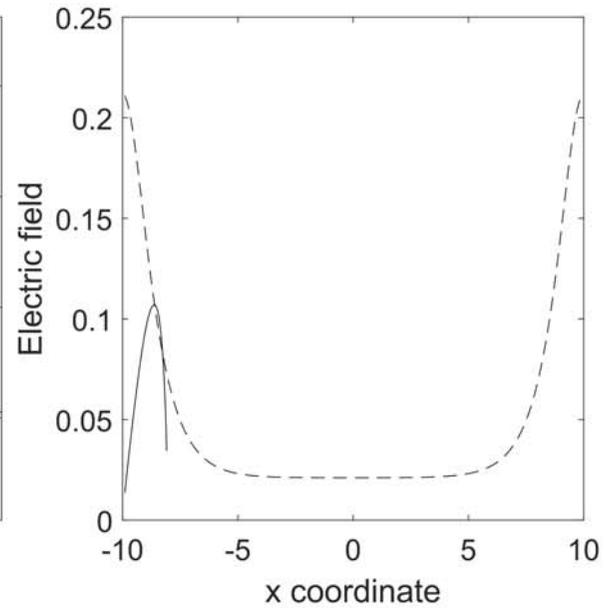
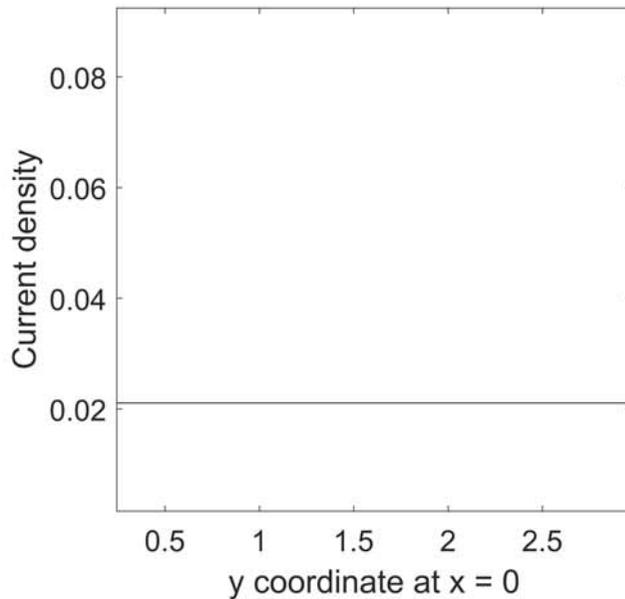
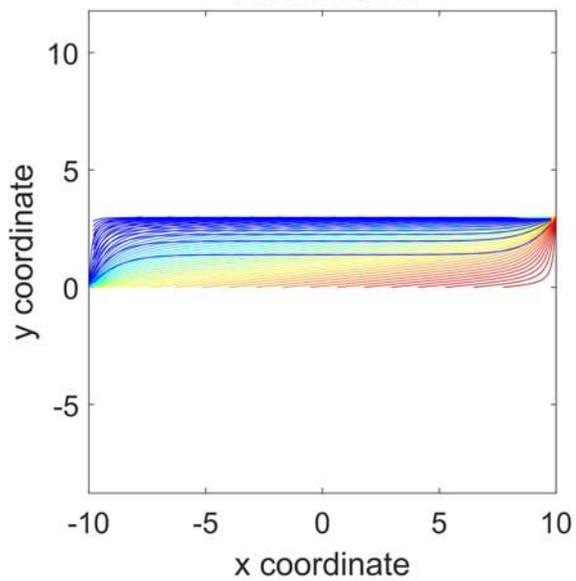
Electric field and equipotential lines



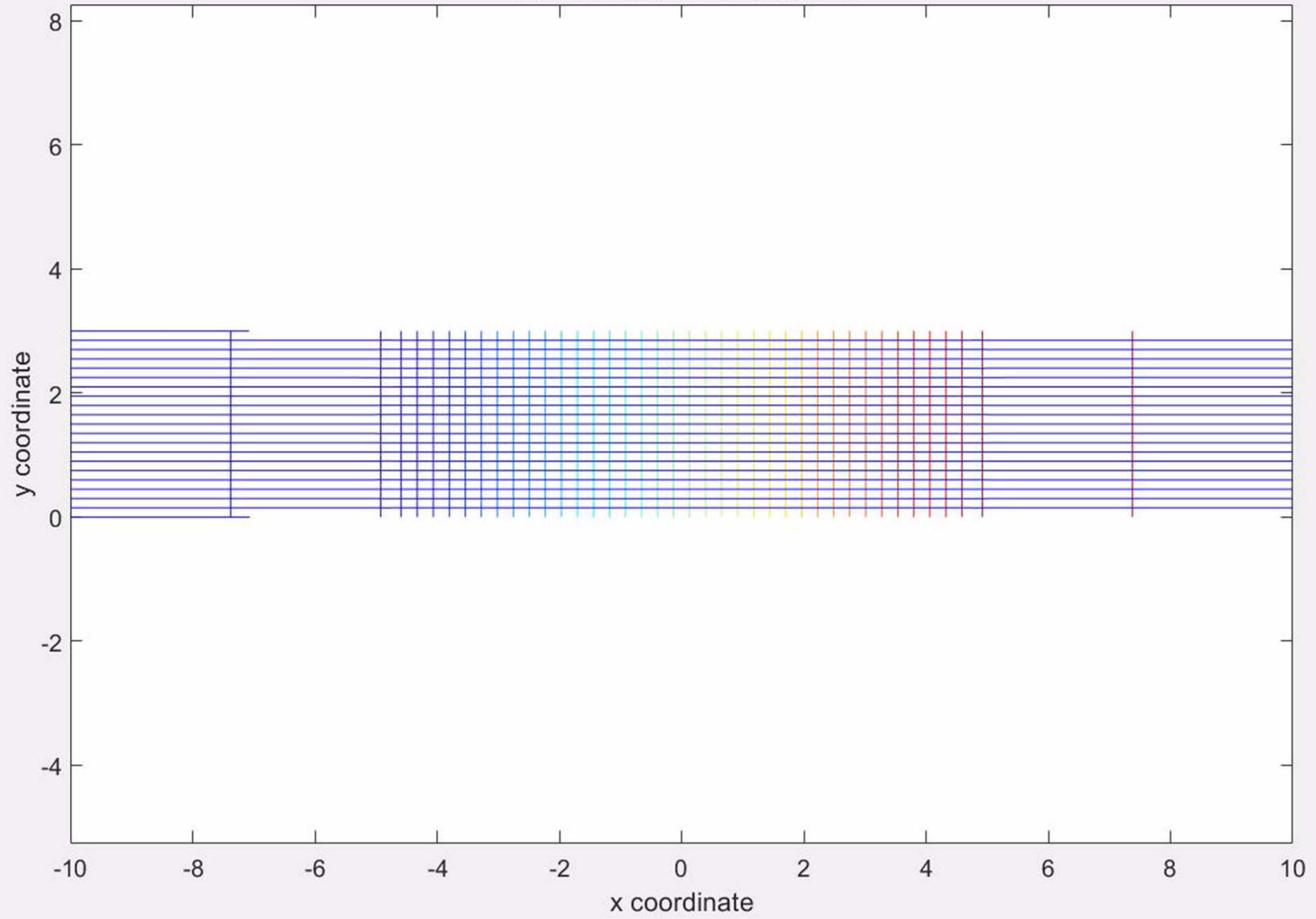
Current density ( $A/m^2$ )



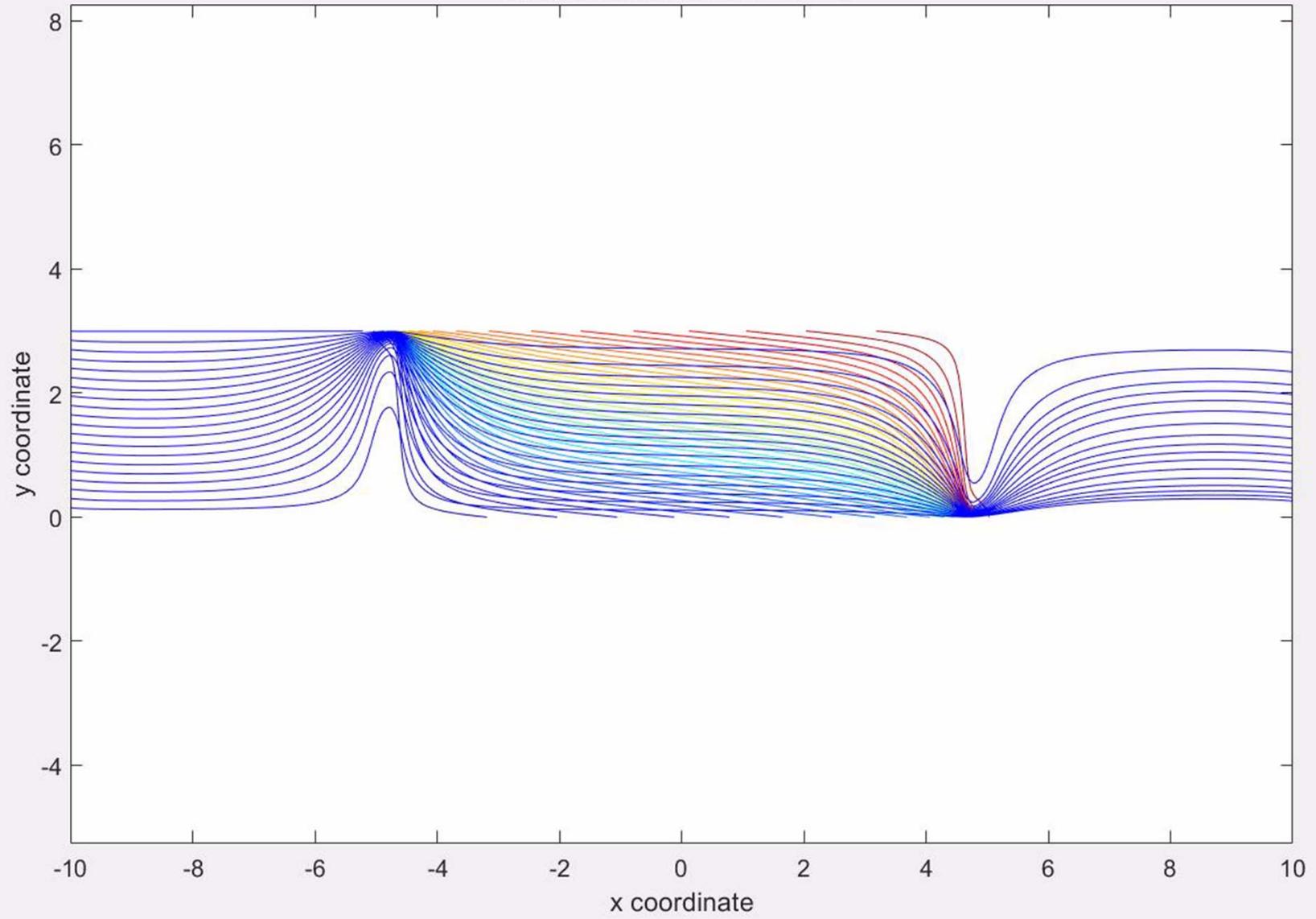
Current flow



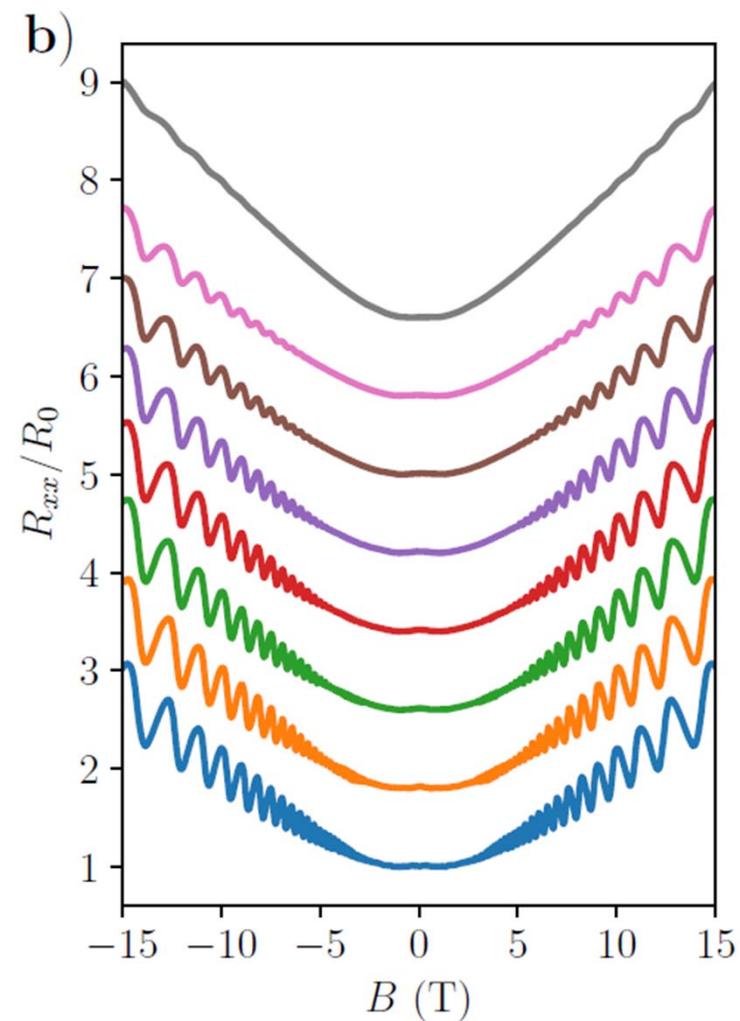
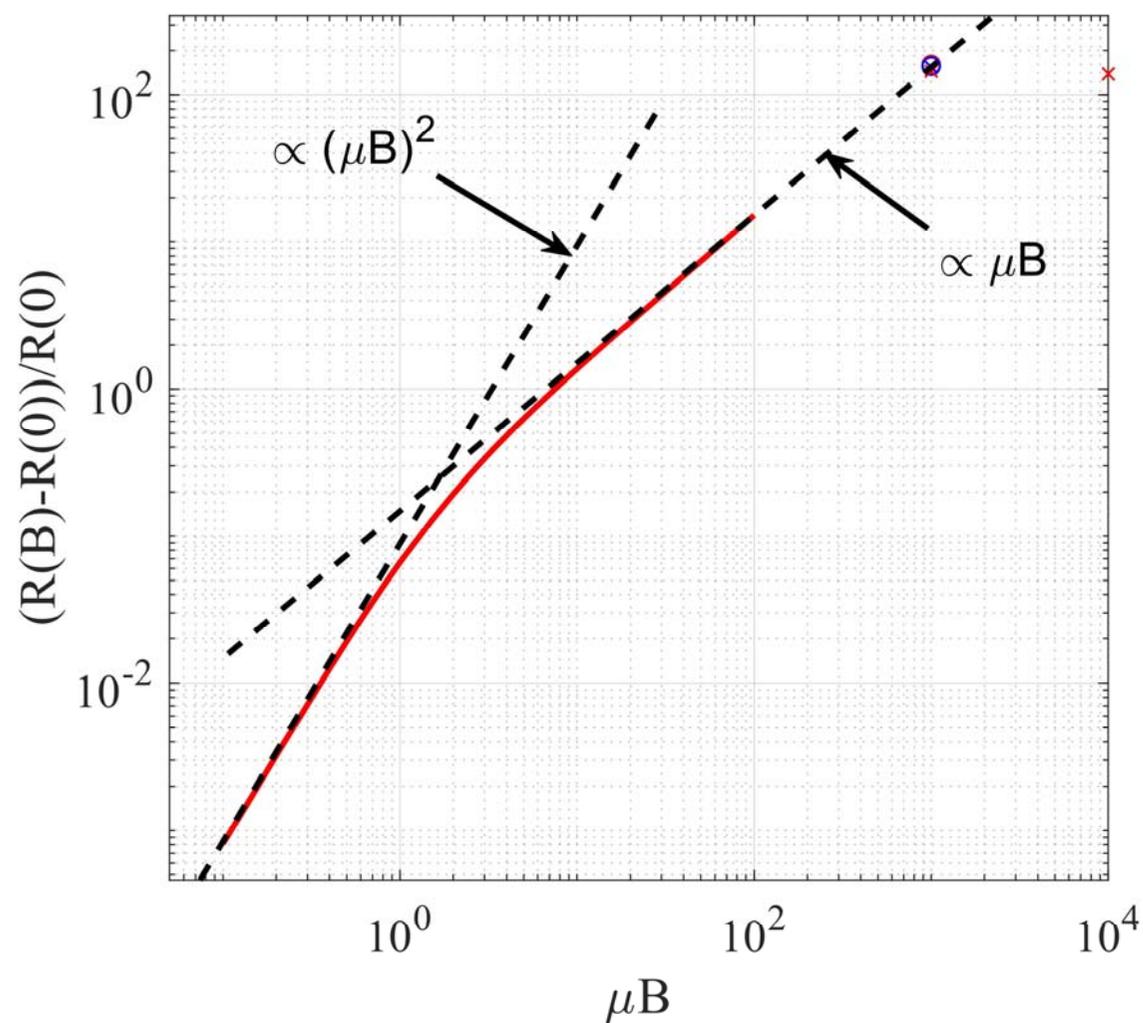
Equipotential lines at  $\mu B = 0$



Equipotential lines at  $\mu B = -10$

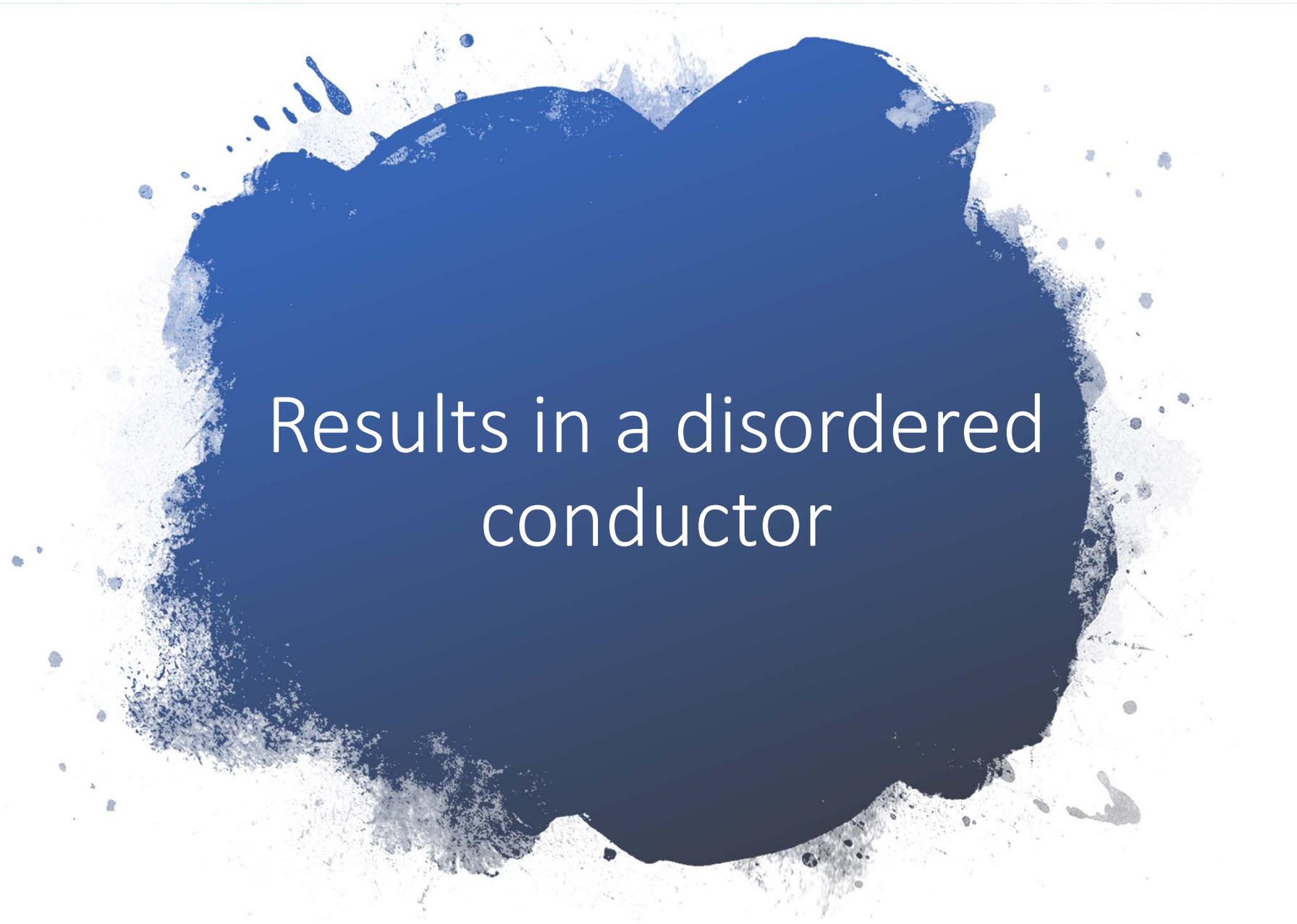


# Quadratic-to-linear magnetoresistance crossover



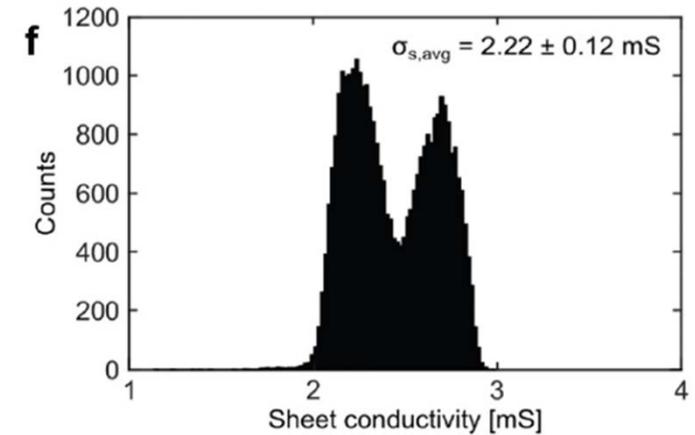
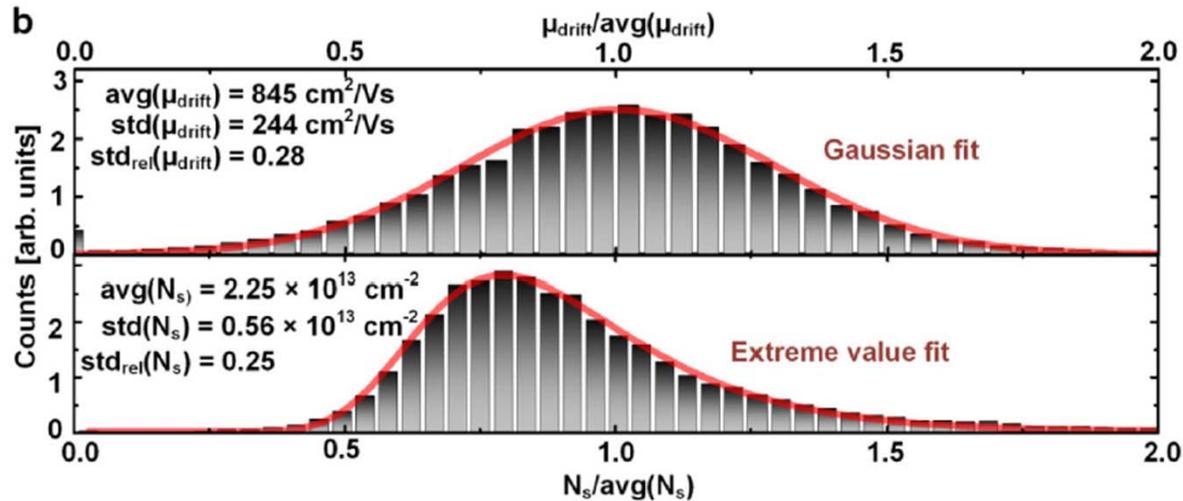
D. Bloos et al., 2D Mater. 6 (2019) 035028

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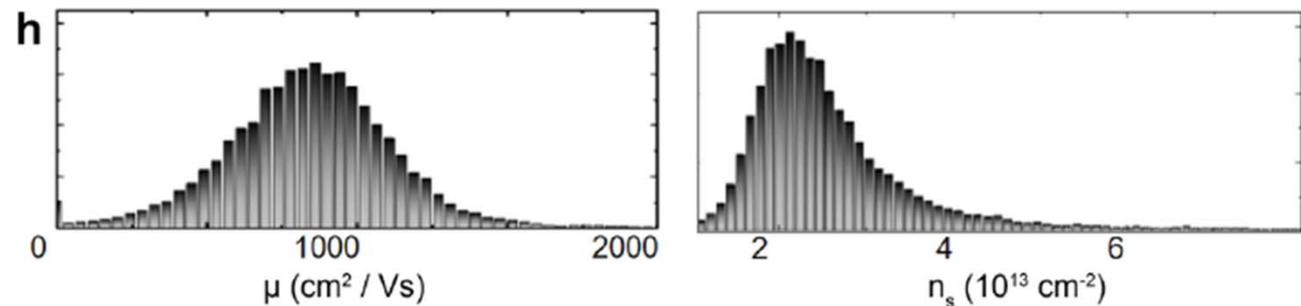


Results in a disordered  
conductor

# How to describe disorder?

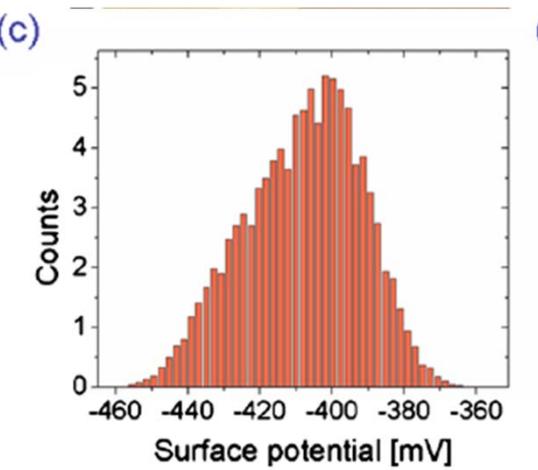


J. D. Buron et al., Optics Express 23 (2015) 30721.



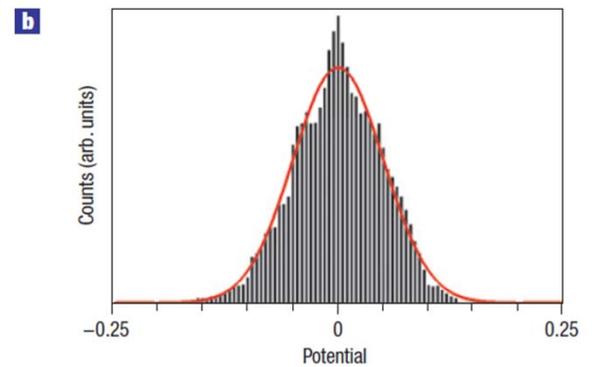
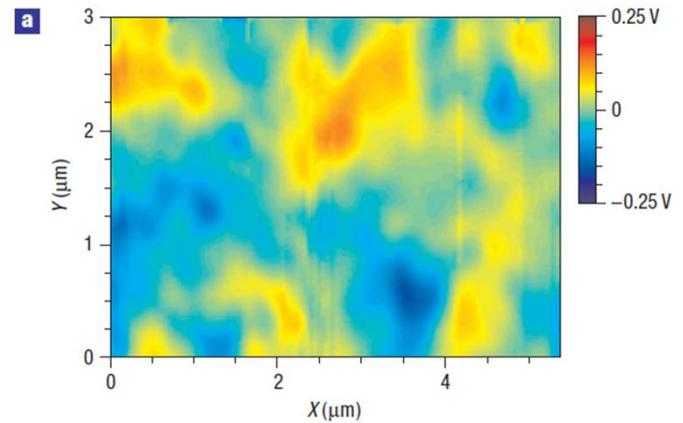
P. Boggild et al., 2D Mater. 4 (2017) 042003.

# How to describe disorder? - Energy fluctuations



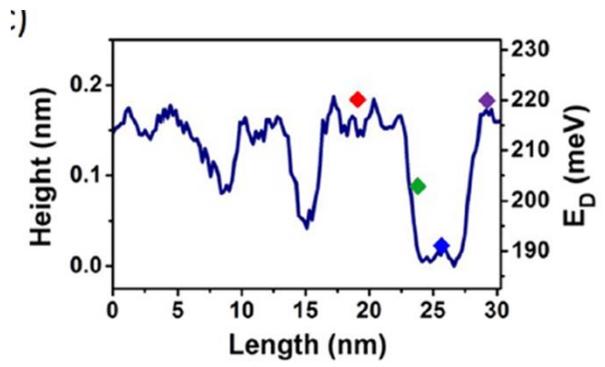
Synthesis (treatment)	Disorder strength (meV)	Probing method
Epitaxial on SiC (CD1)	$12.7 \pm 0.6$	Magnetotransport
Epitaxial on SiC (CD2)	$10.2 \pm 0.4$	Magnetotransport
Epitaxial on SiC (UV1)	$31.3 \pm 2.0$	Magnetotransport
Epitaxial on SiC (AO)	$15 \pm 1$	Magnetotransport
Epitaxial on SiC	12	KPM [5]
Exfoliated on SiO <sub>2</sub> /Si	50	SET [6]
Exfoliated on SiO <sub>2</sub> /Si	~20	STM [7]
Exfoliated on h-BN	5.4	STM [8]
CVD on Ir(111)	~30	STM/STS [9]

J. Huang et al., Phys. Rev. B 92 (2015) 075407.



J. Martin et al. Nat. Phys. 4 (2008) 144.

A. E. Curtin et al., Appl. Phys. Lett. 98 (2011) 243111.

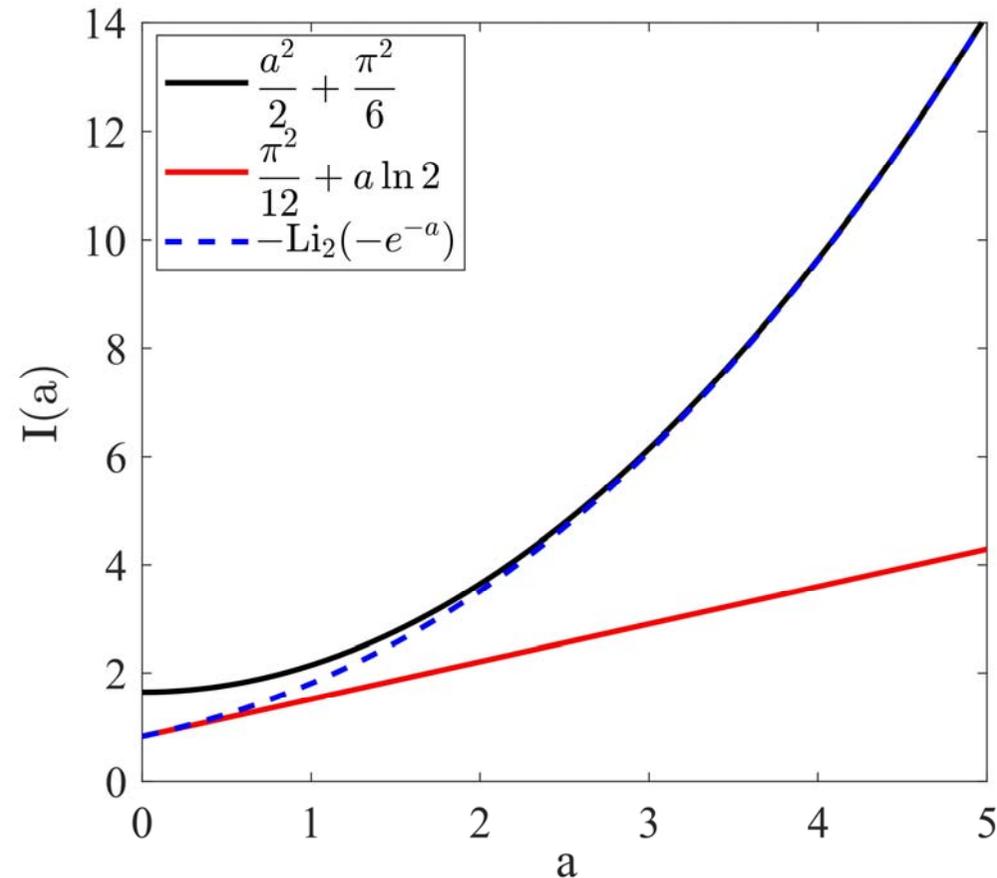


Rajput, Appl. Phys. Lett. 104 (2014) 041908.

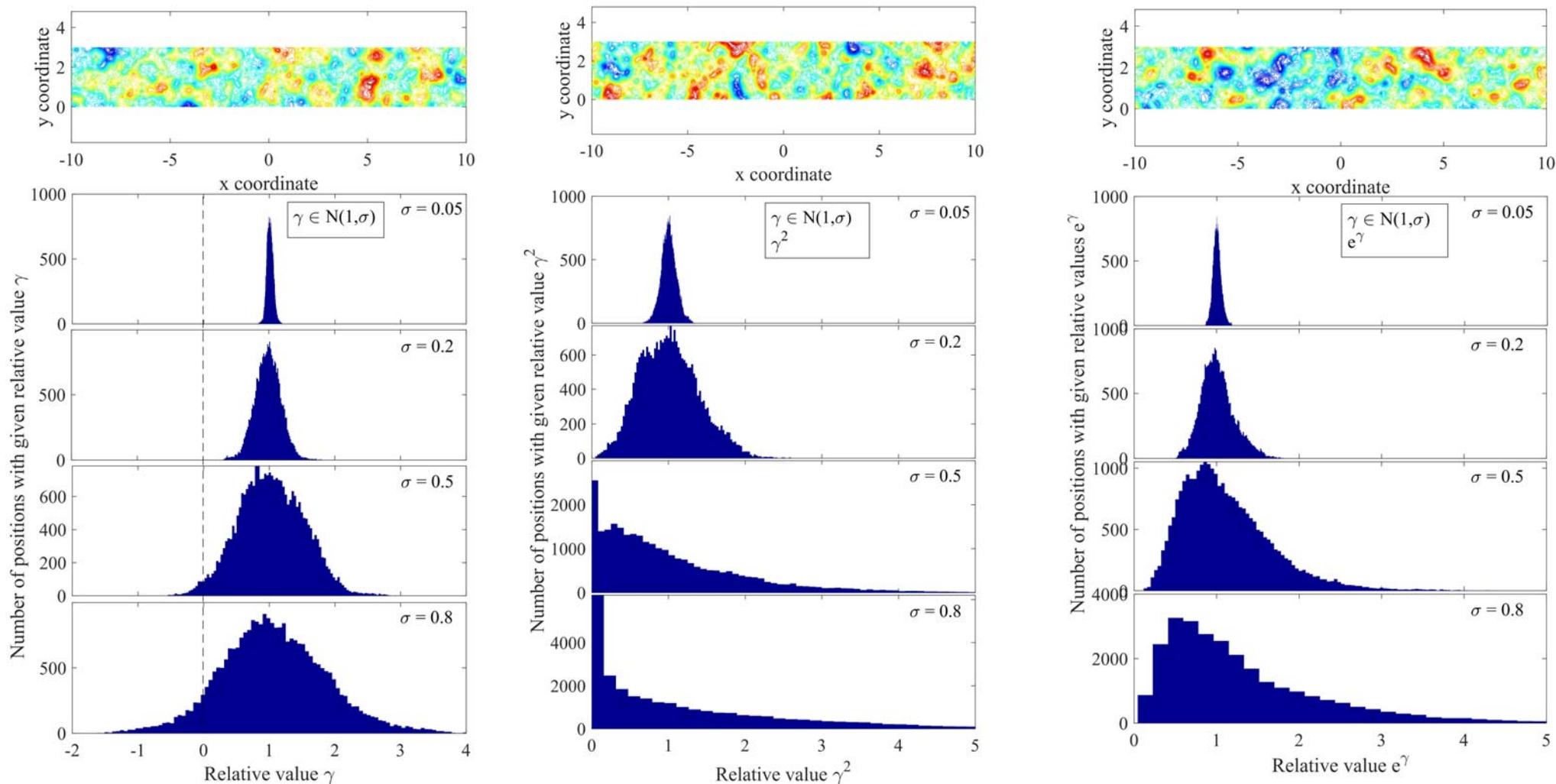
# Carrier density fluctuations in graphene

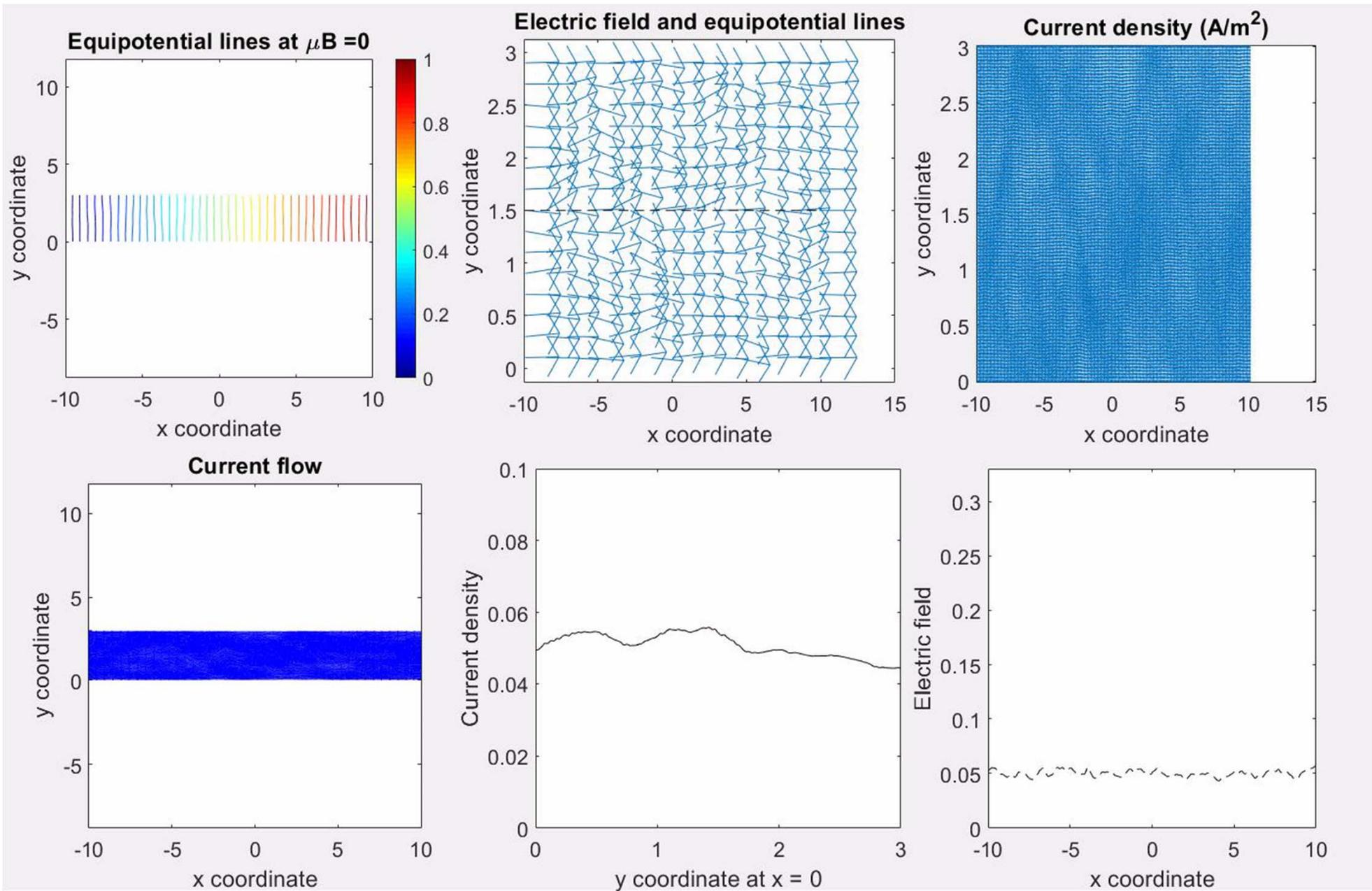
$$n_{2D} = \frac{2(k_B T)^2}{\pi(\hbar v_F)^2} I(a)$$

$$a = E_F/k_B T$$

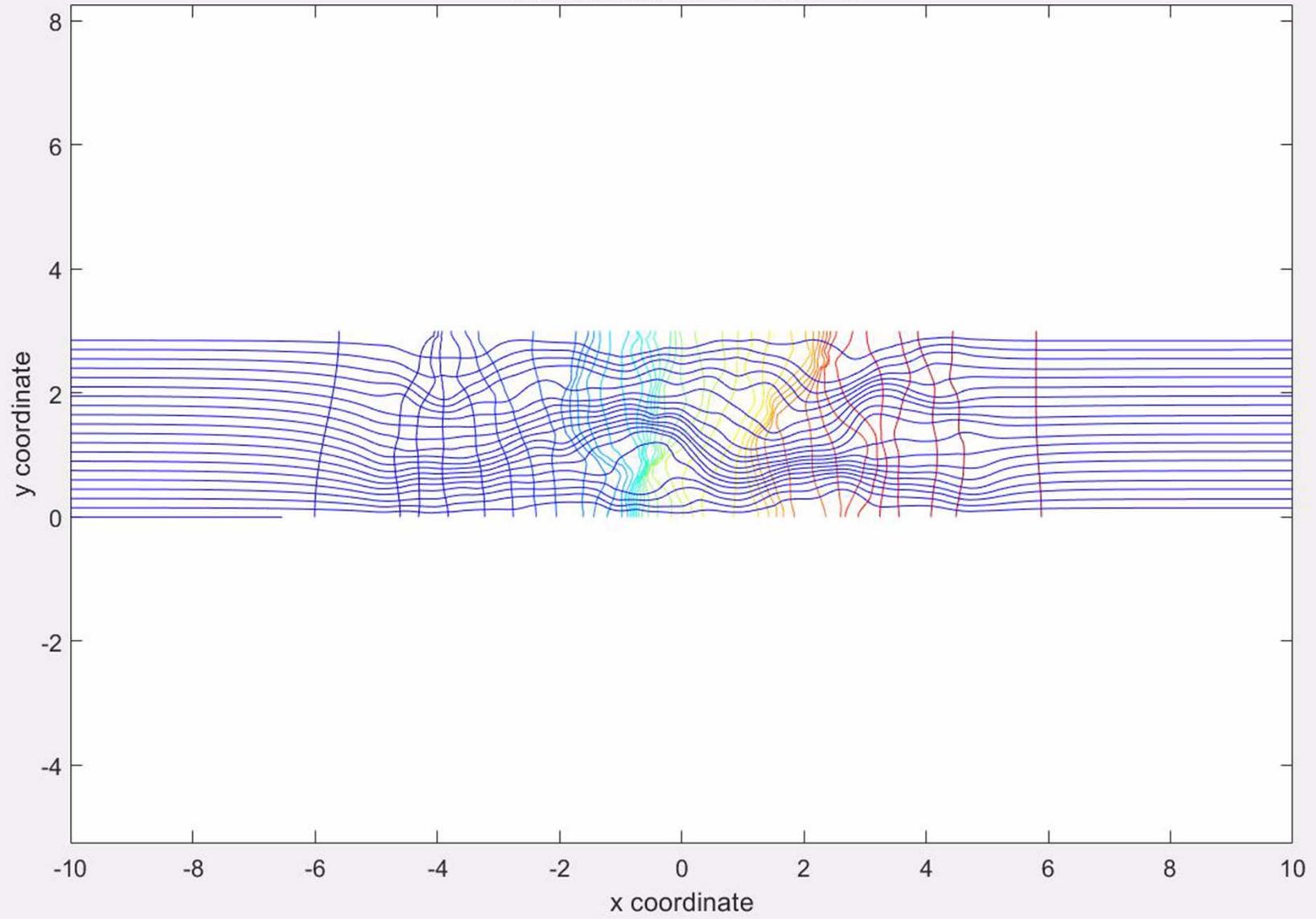


# Distribution functions describing disorder

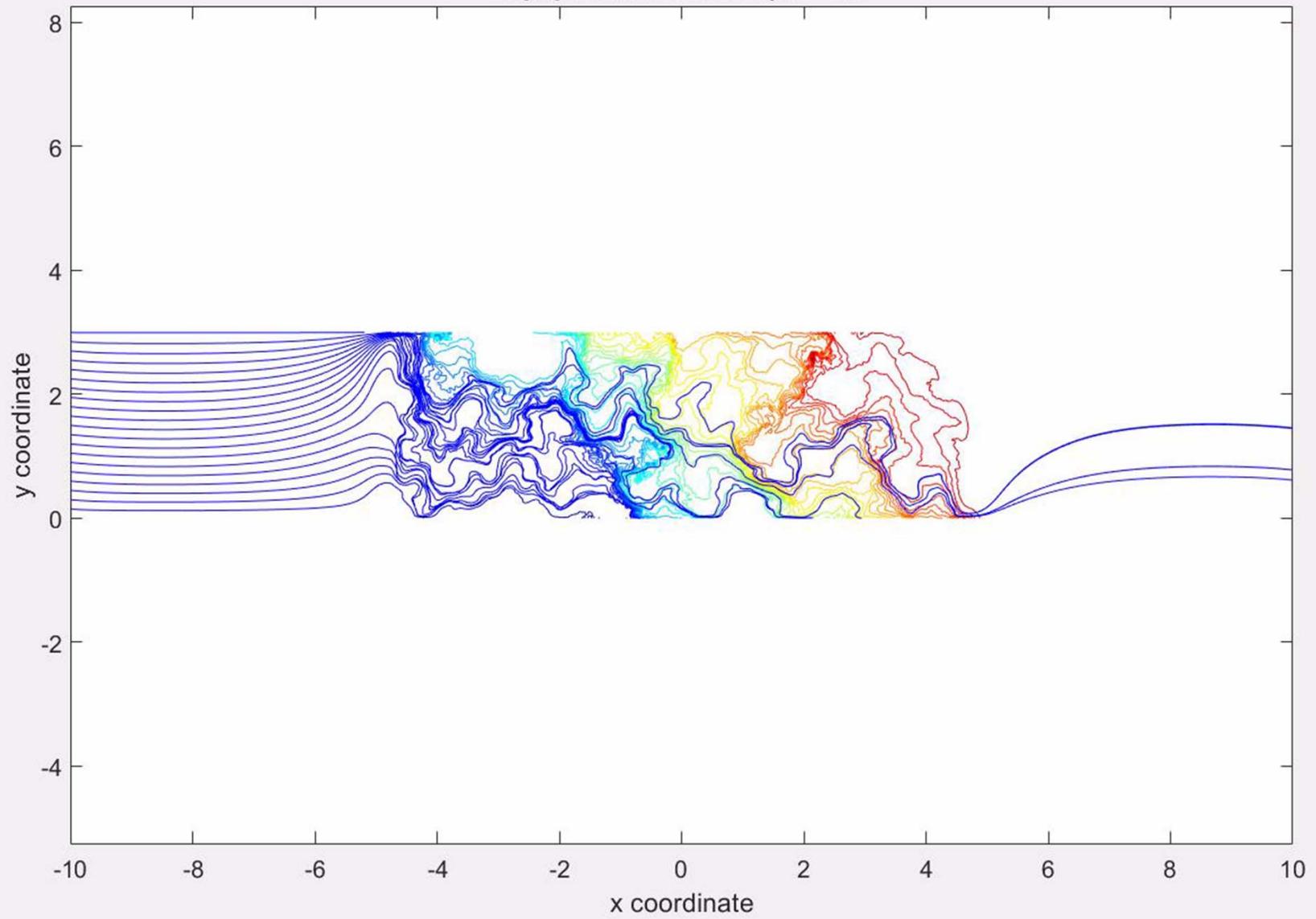




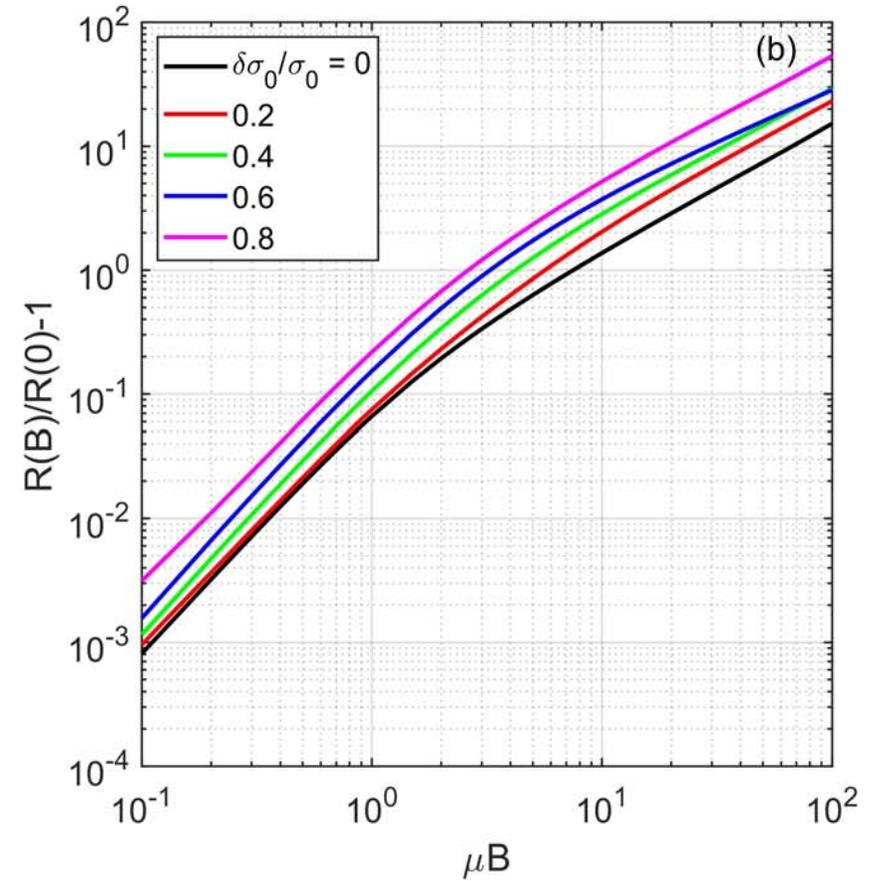
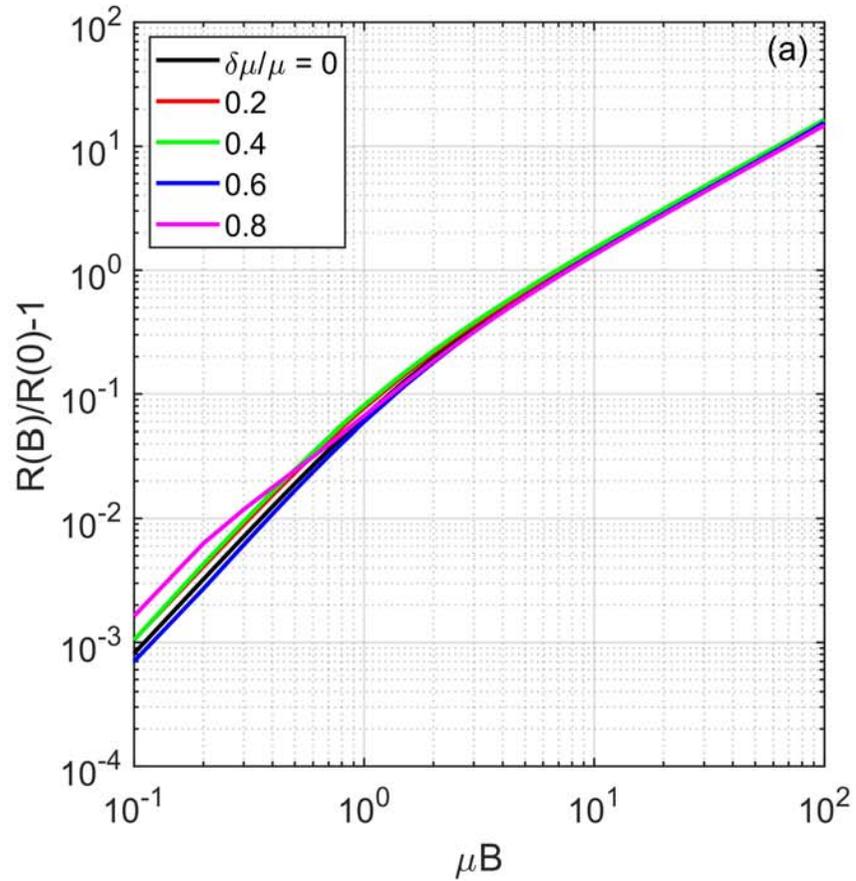
Equipotential lines at  $\mu B = 0$



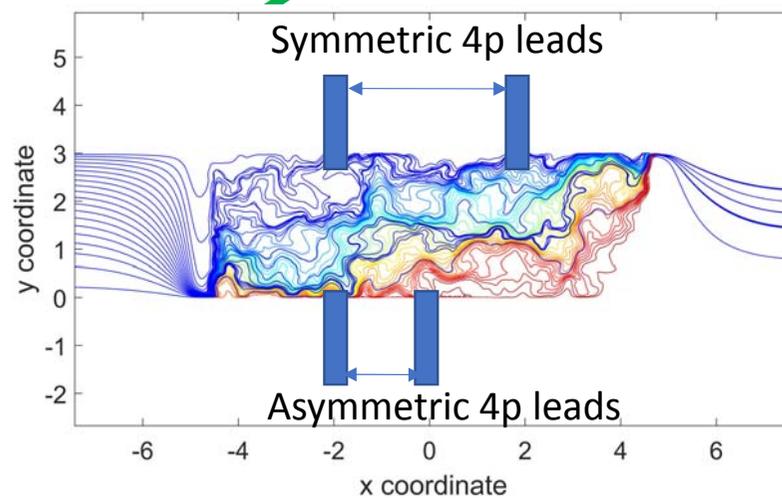
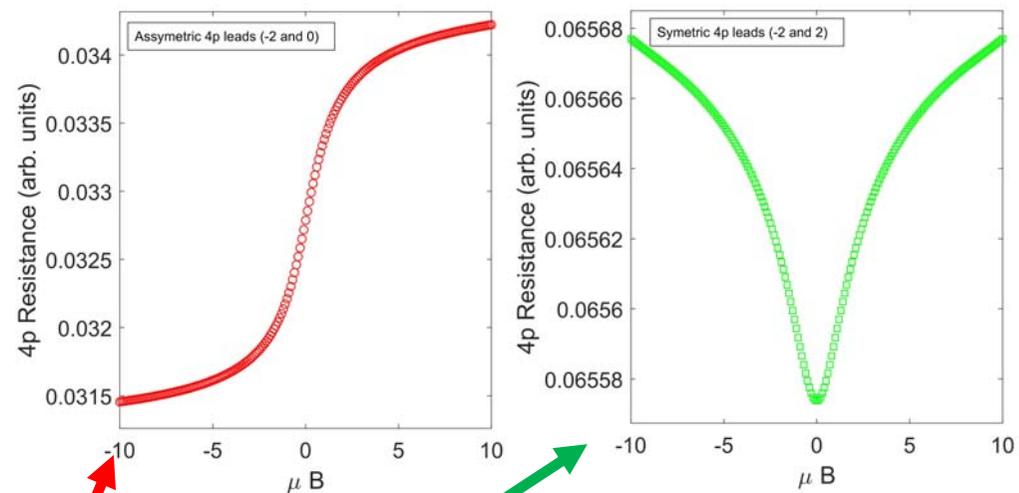
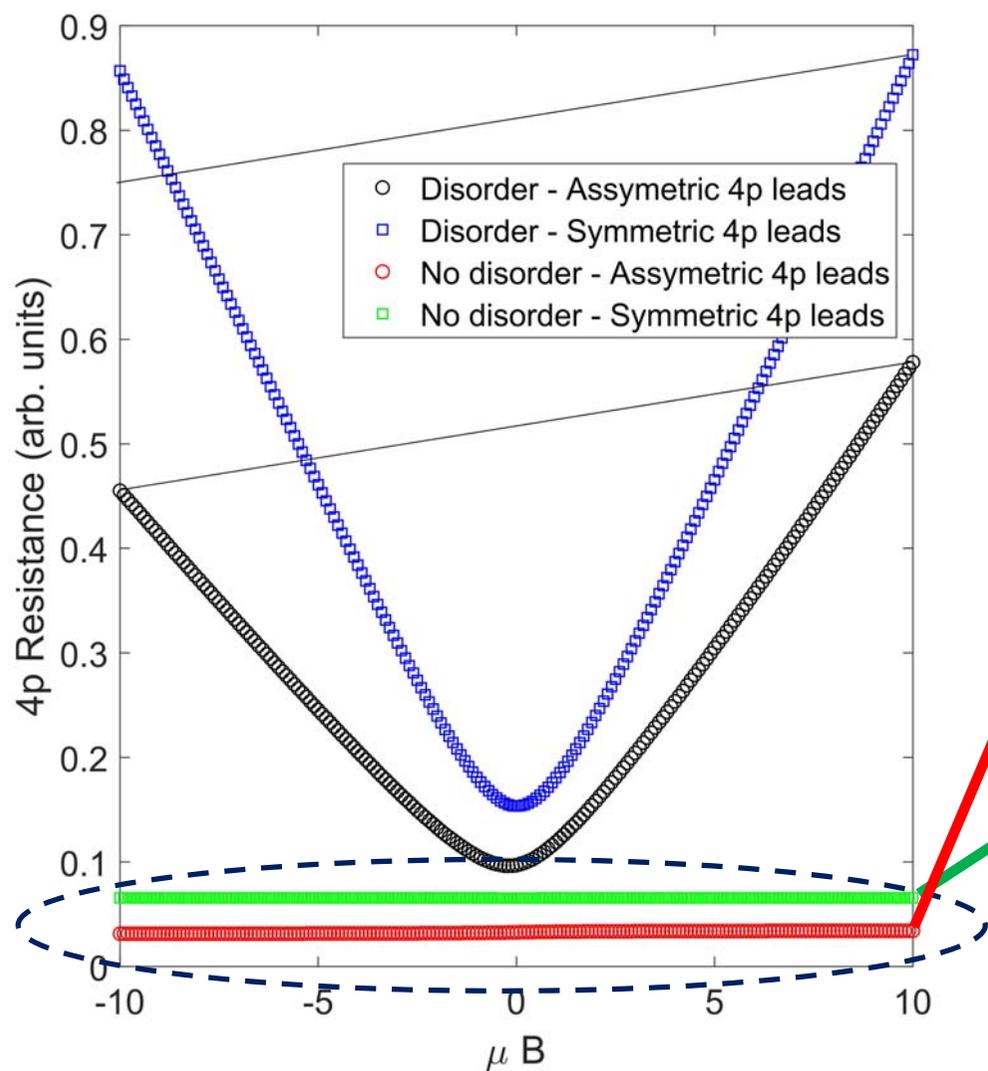
Equipotential lines at  $\mu B = -10$



# Mobility and conductivity fluctuations



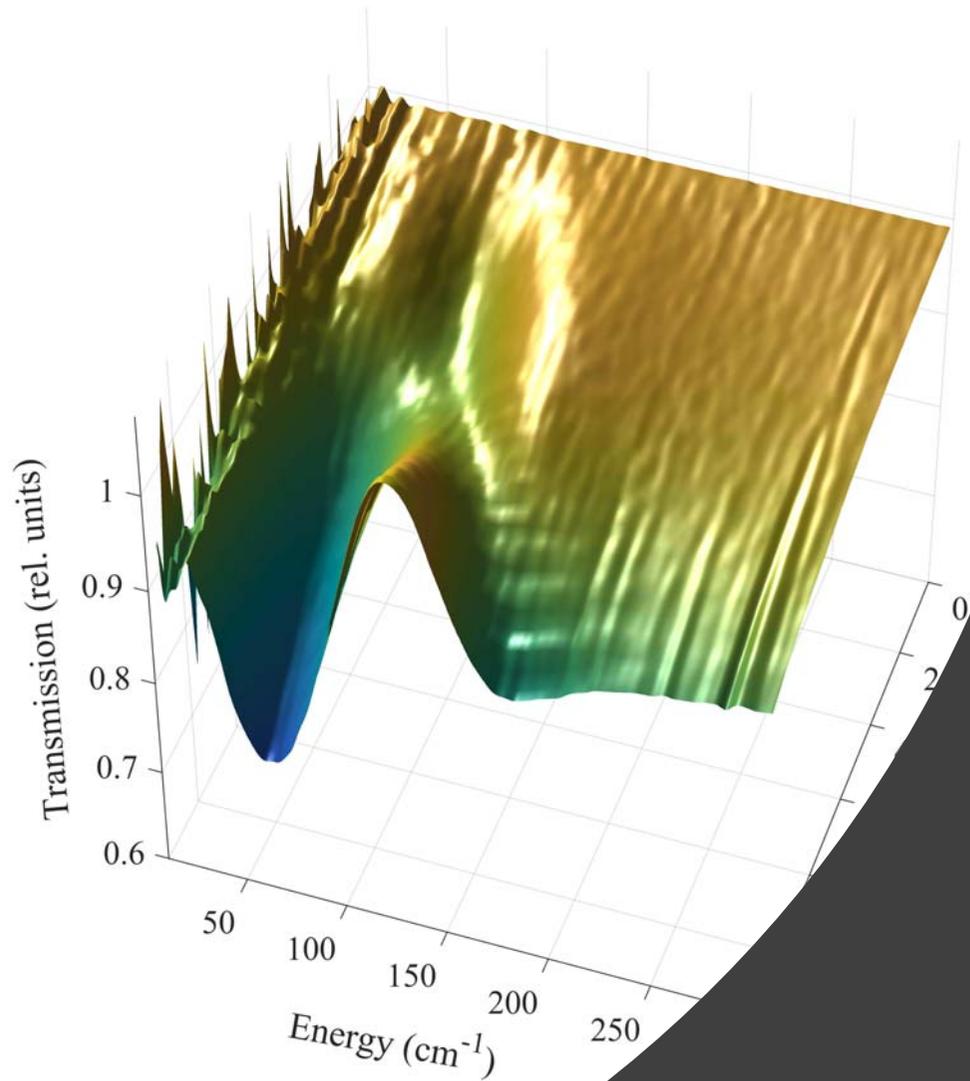
# 4 point measurements



# Conclusions:

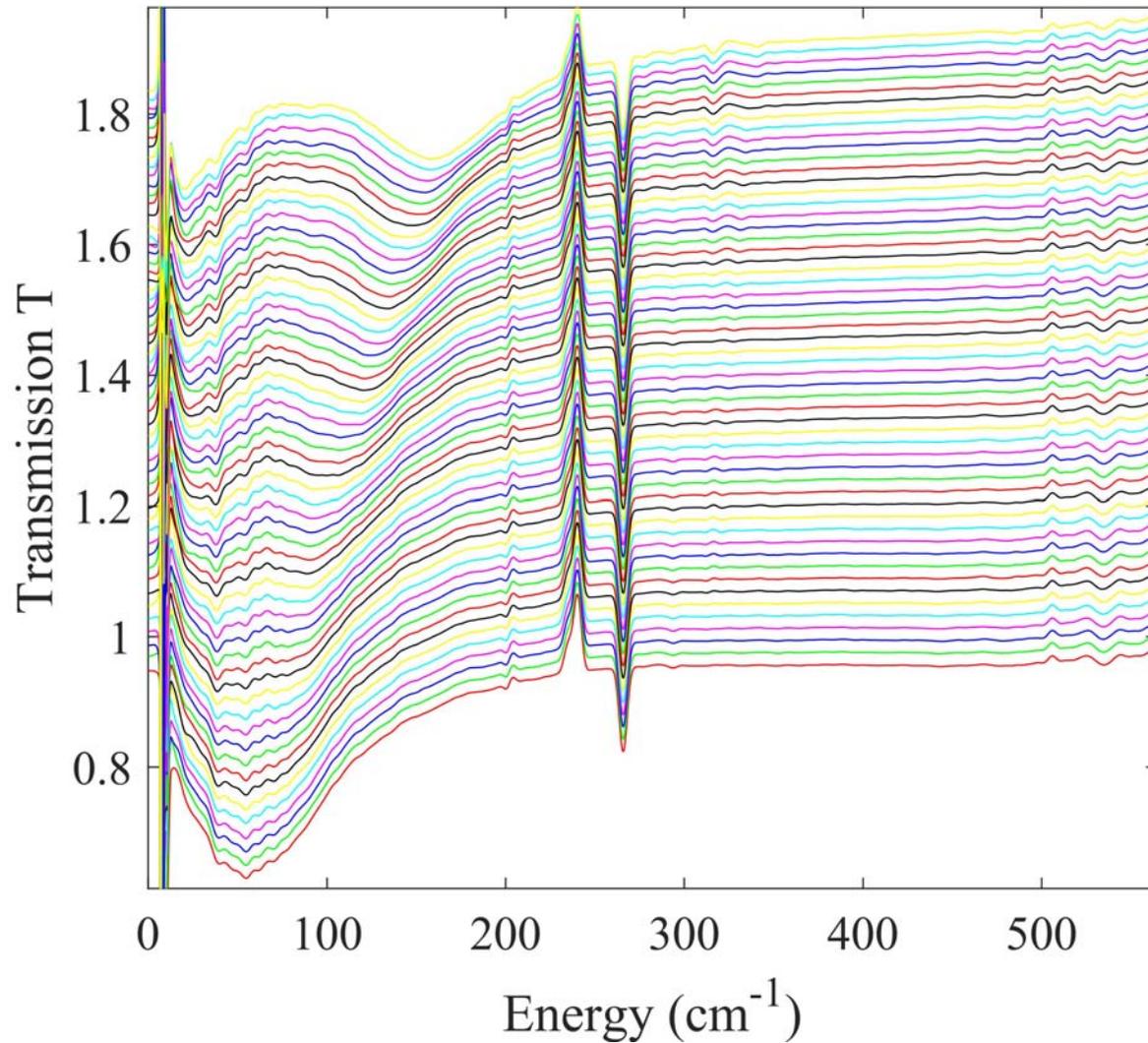
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- Quadratic to linear magnetoresistance crossover is caused solely by finite size geometry in a 2-point measurements
- The crossover occurs at about  $\mu B = 1$
- Fluctuations of conductivity and mobility play a role in the magnetoresistance (both quadratic and linear), however; the role is minor in a two-point measurements.
- The role of disorder is crucial in a four-point measurements
- Asymmetry of the MR in 4-point measurements is also due to the non-axial location of voltage-sensing leads.
- Temperature dependence of MR is given by the temperature dependence of zero-field conductivity and mobility



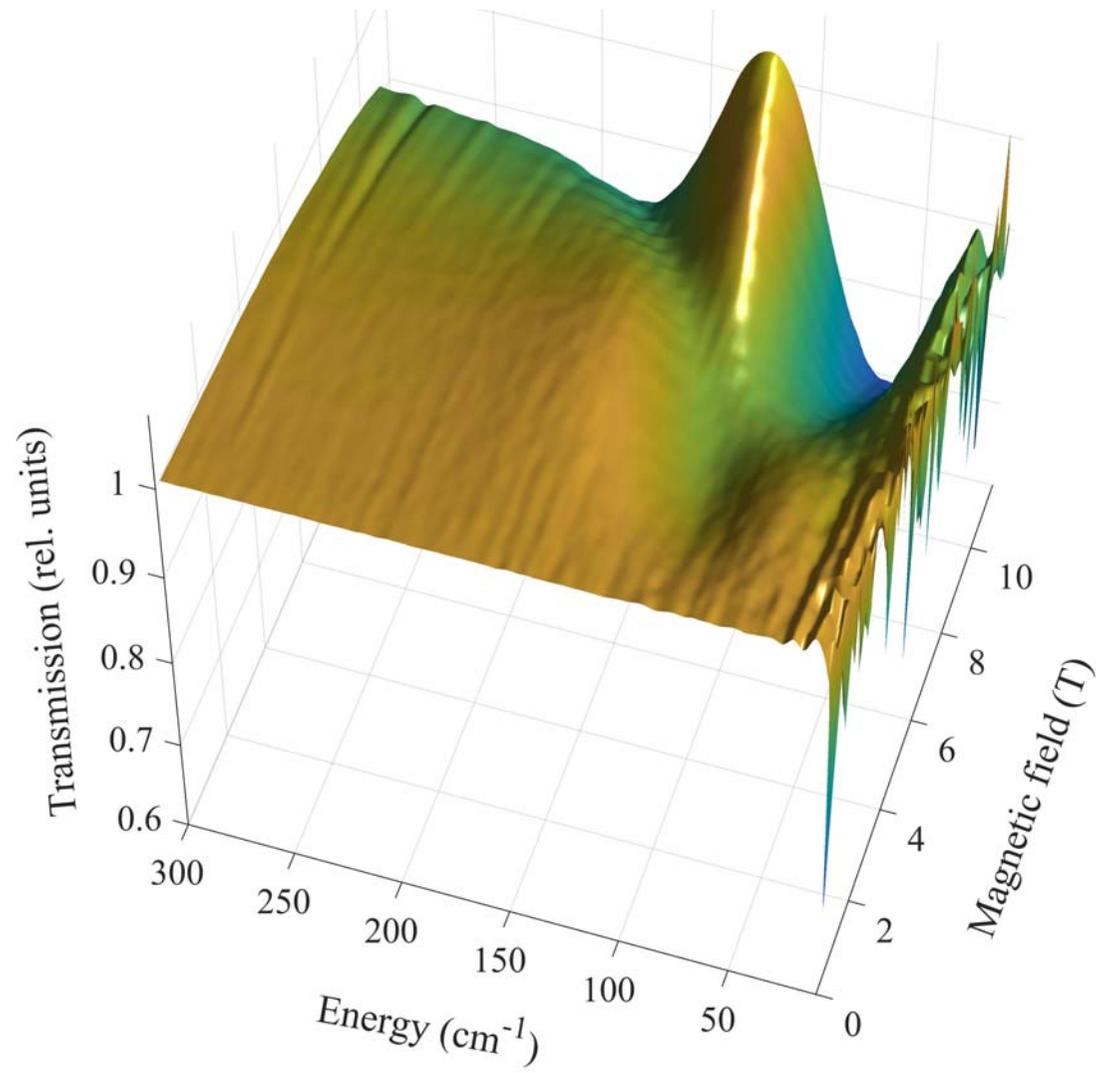
Magneto-  
plasmons in  
graphene

# Transmittance

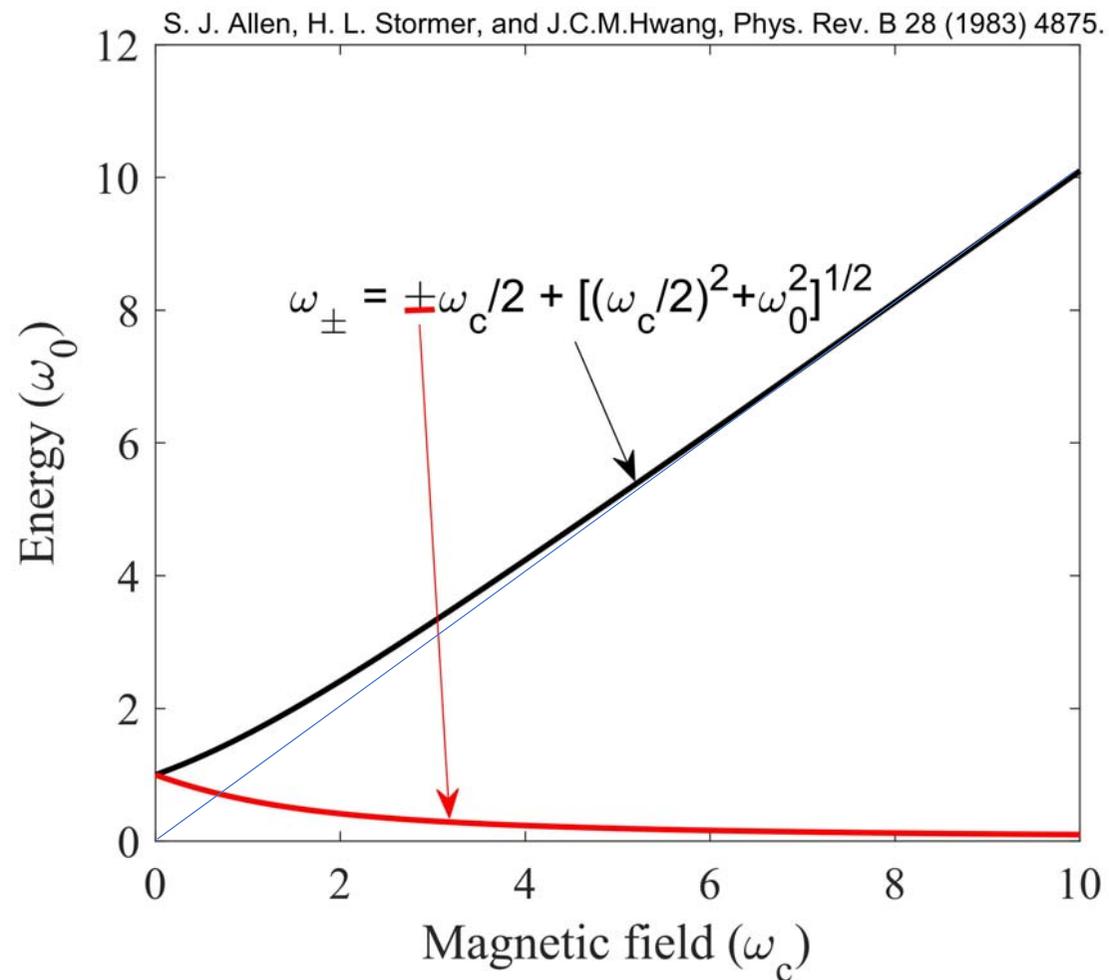
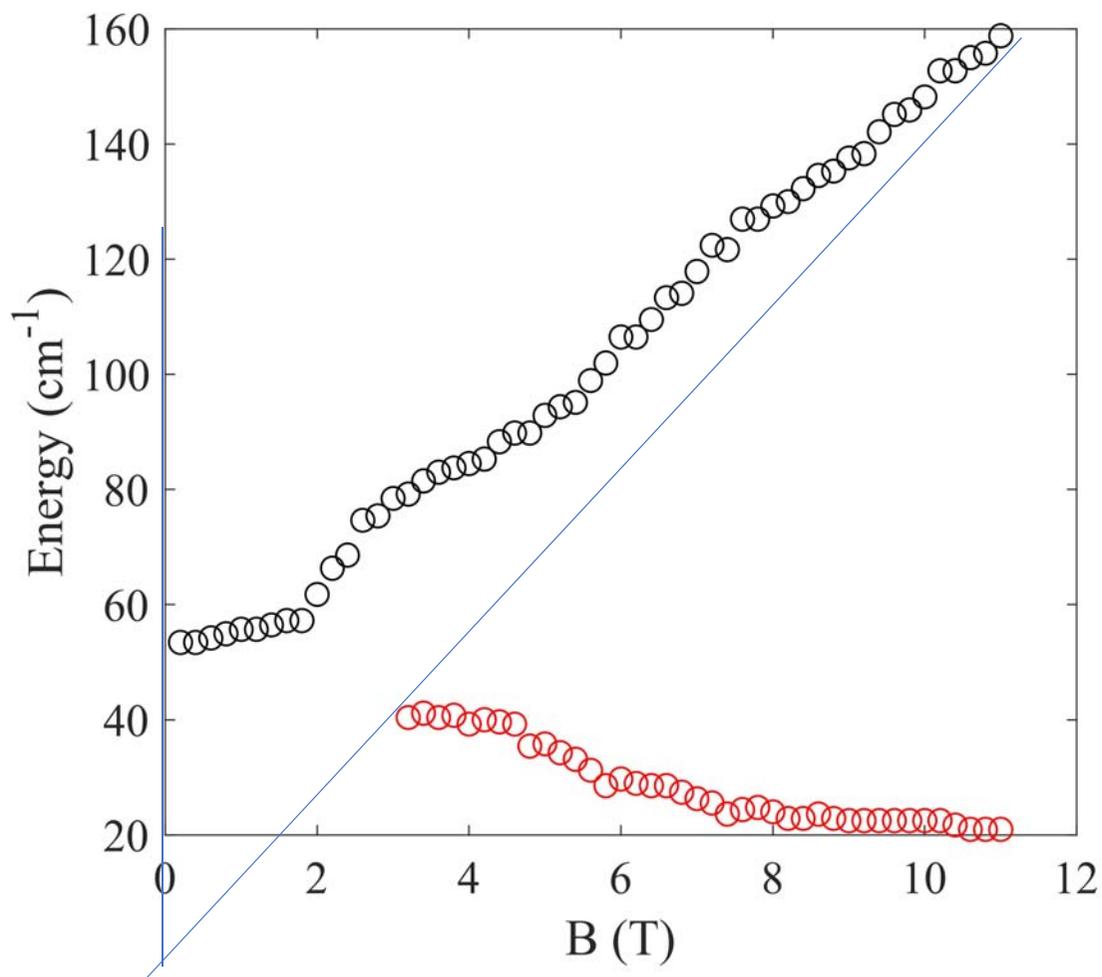


- Hydrogen intercalated buffer on SiC(0001) = quasi free-standing monolayer graphene
- The translational invariance broken by SiC step edges
- Single absorption peak at 50/cm at 0 T
- The absorption peak splits in two components (upper and lower branches)  
=> magneto-plasmon

# Relative-to-0T transmittance



# Comparison with theory



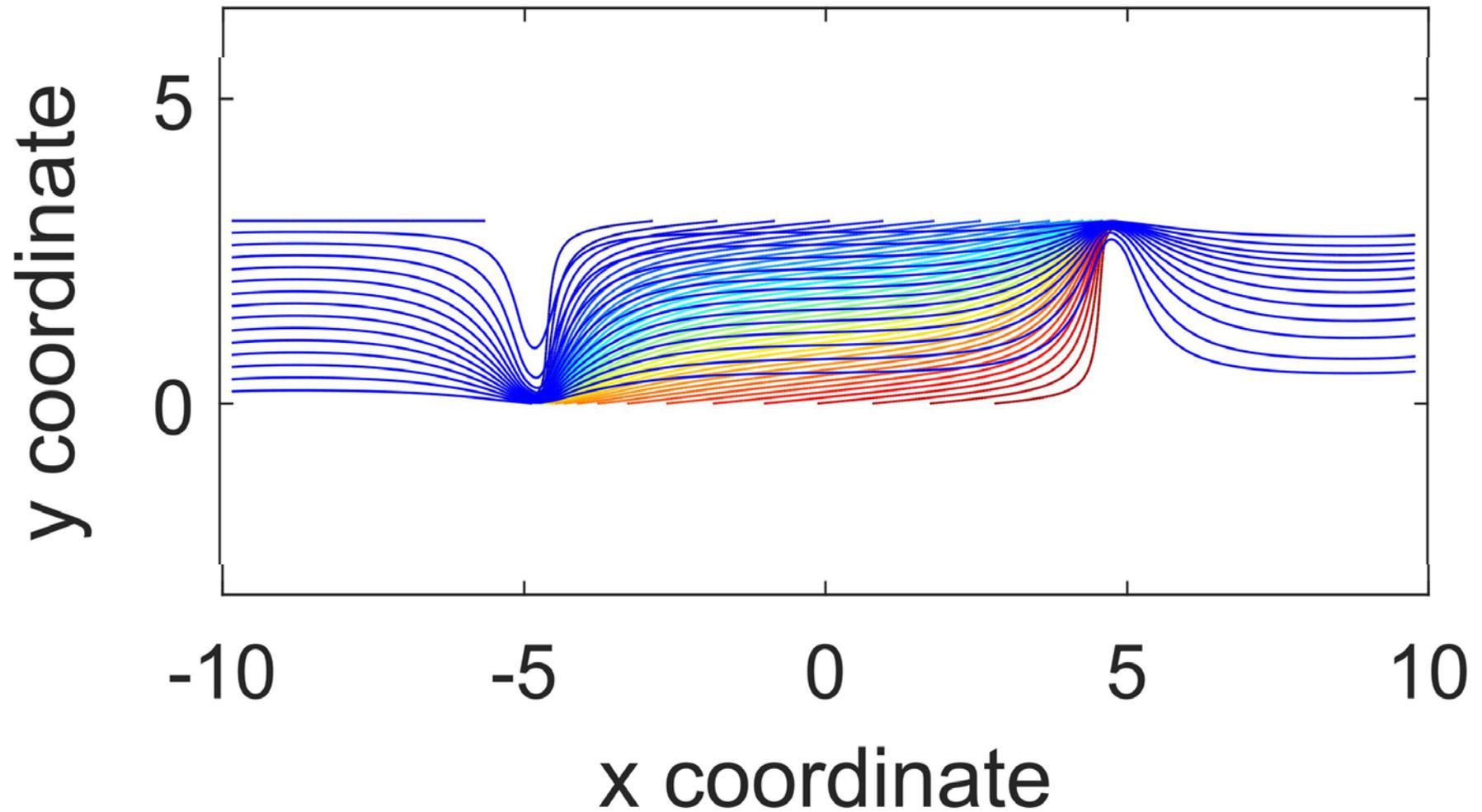
# Conclusions:

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- We have observed plasmon resonance at zero magnetic field in quasi free-standing monolayer graphene on SiC
- The splitting of the plasmon resonance at high magnetic field corresponds to the lower and upper branch of magneto-plasmon
- Magneto-plasmon branches are qualitatively well-described by analytical theory.

# Effect of external leads

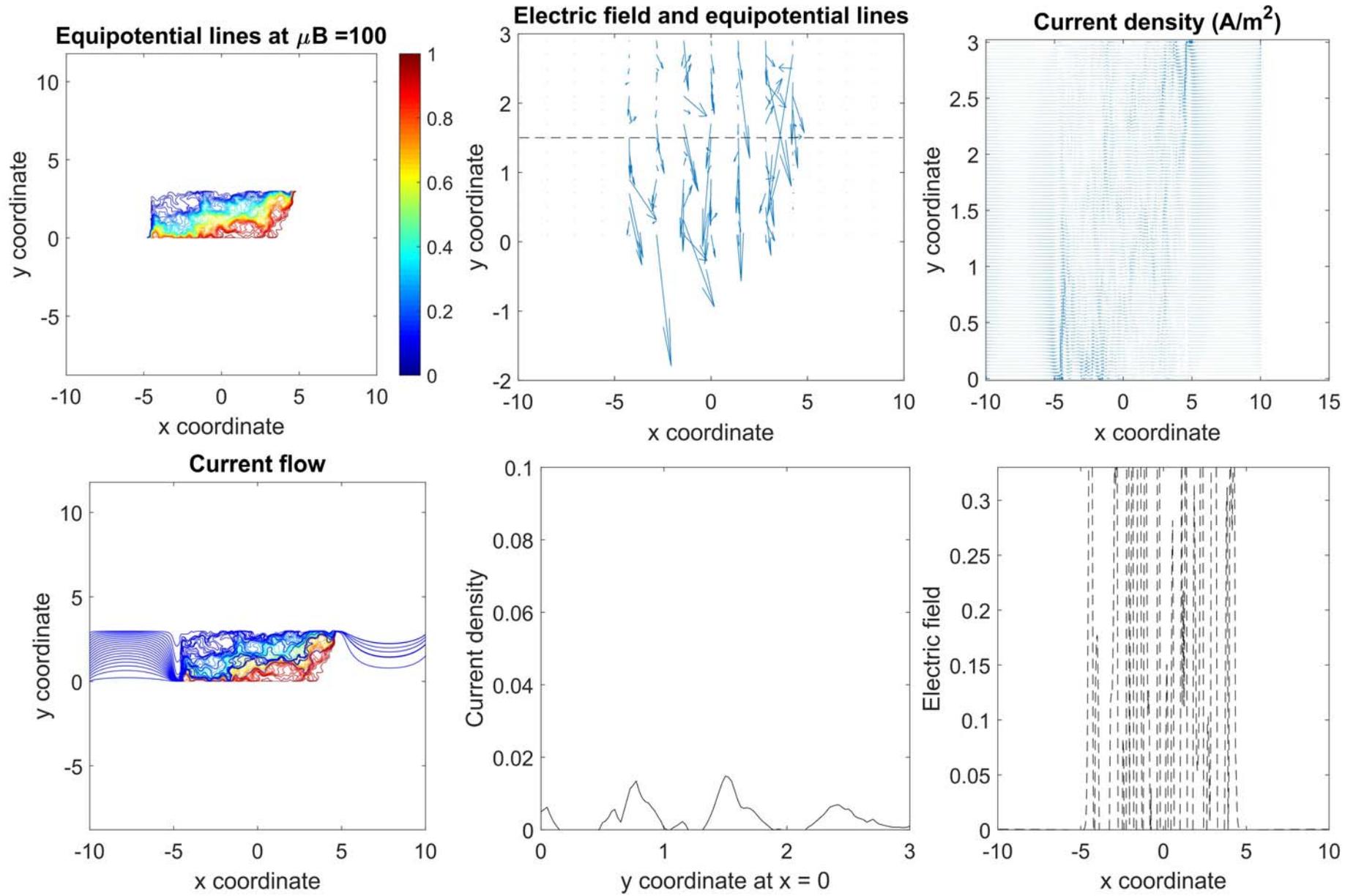
## Current flow



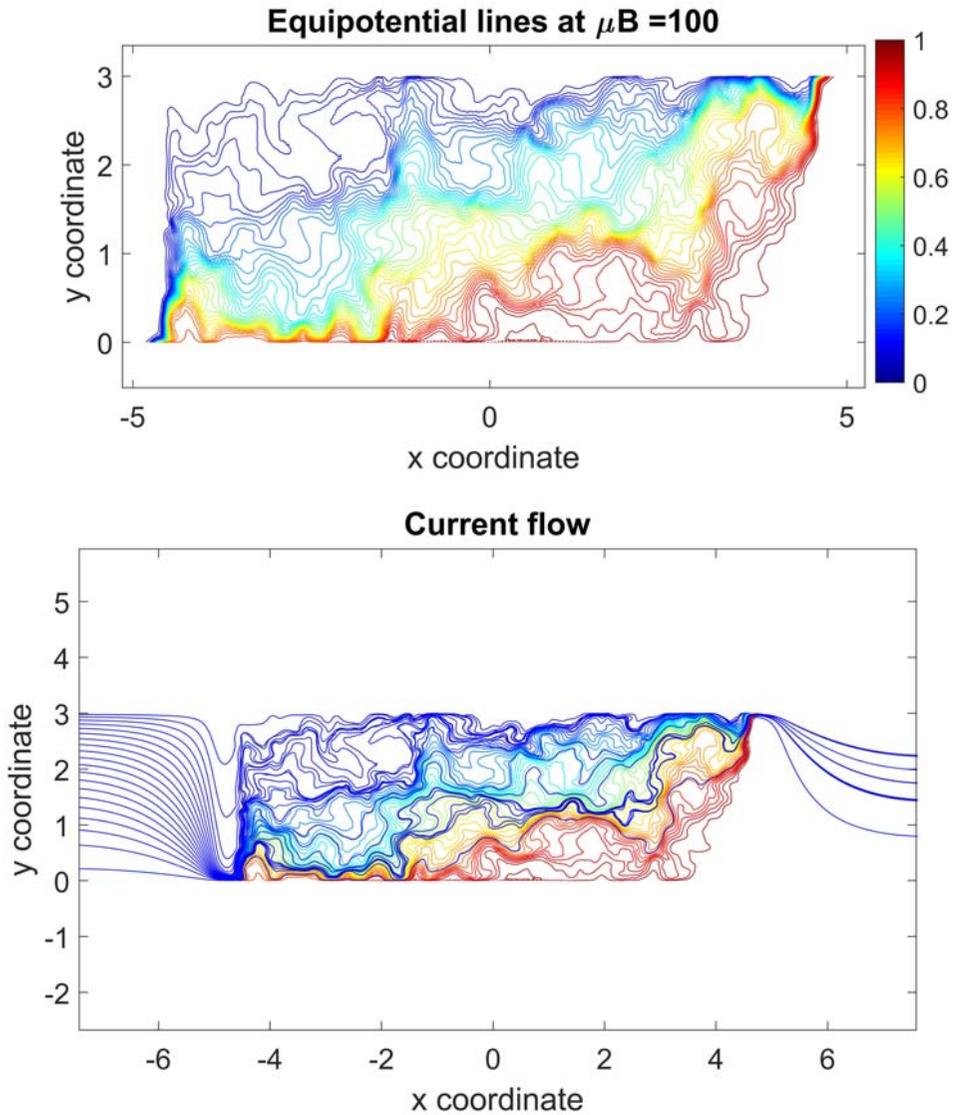
# Historical perspectives

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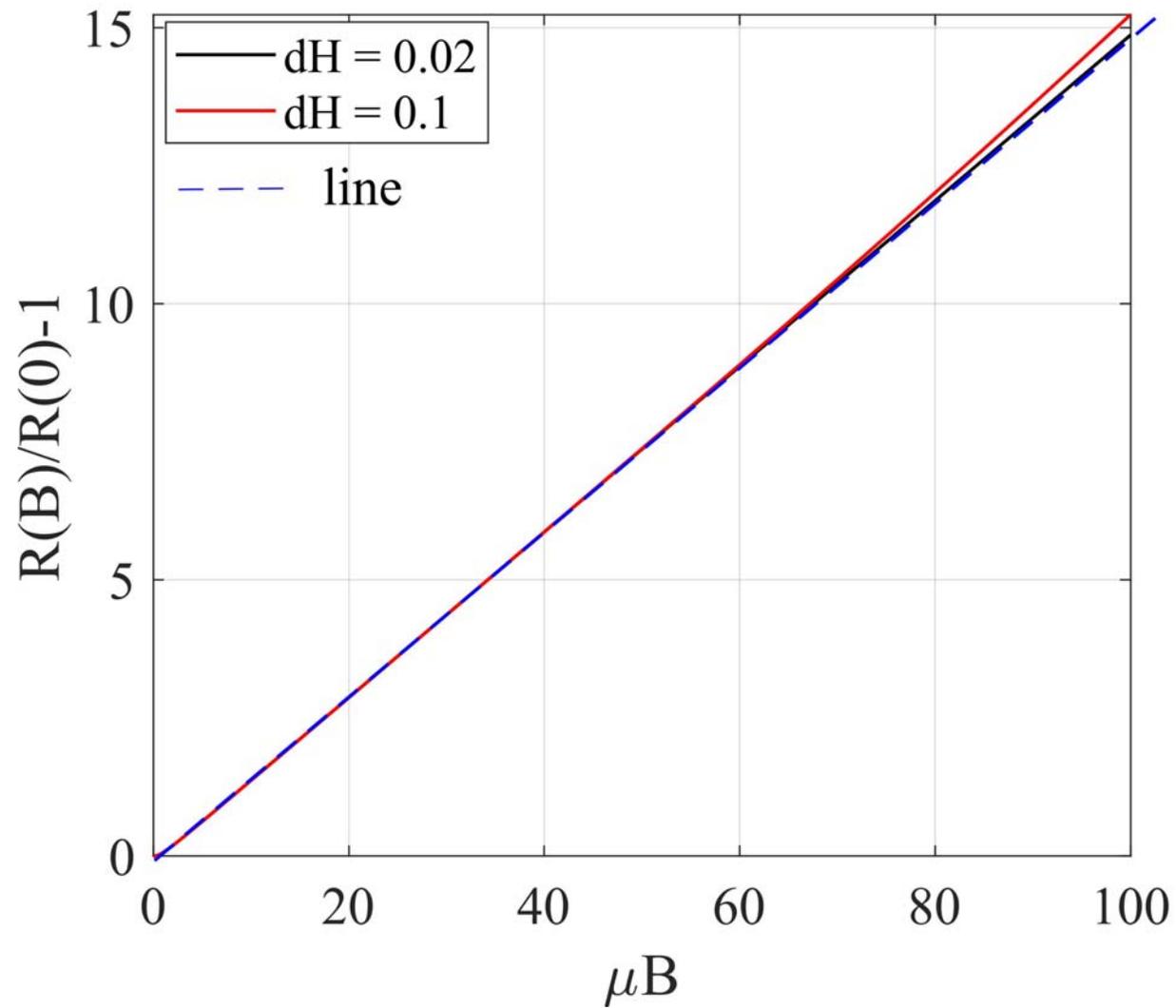
- Li et al. RSC Adv. 7 (2017) 26434, Linear magnetoresistance in gold foams
- Narayanan et al. Phys. Rev. Lett. 114 (2015) 117201, Linear Magnetoresistance caused by mobility fluctuations in n-doped Cd<sub>3</sub>As<sub>2</sub>
- Raichev, Phys. Rev. B 97 (2018) 245310, Effect of Landau quantization on linear magnetoresistance of a periodically modulated two-dimensional electron gas
- Simon, Halperin, Phys. Rev. Lett 73 (1994) 3278, relation between diagonal and off-diagonal conductivity
- Tieke et al. Phys. Rev. Lett. 78 (1997) 4621, relation between electrical and thermoelectric properties
- Song et al. Phys. Rev. B 92 (2015) 180204(R), Linear magnetoresistance in metals: Guiding center diffusion in a smooth random potential.



# Highly disordered conductor



# Numerical precision



# Measured current distribution in graphene

